



MONASH  
University



F L E E T  
ARC CENTRE OF EXCELLENCE IN  
FUTURE LOW-ENERGY  
ELECTRONICS TECHNOLOGIES

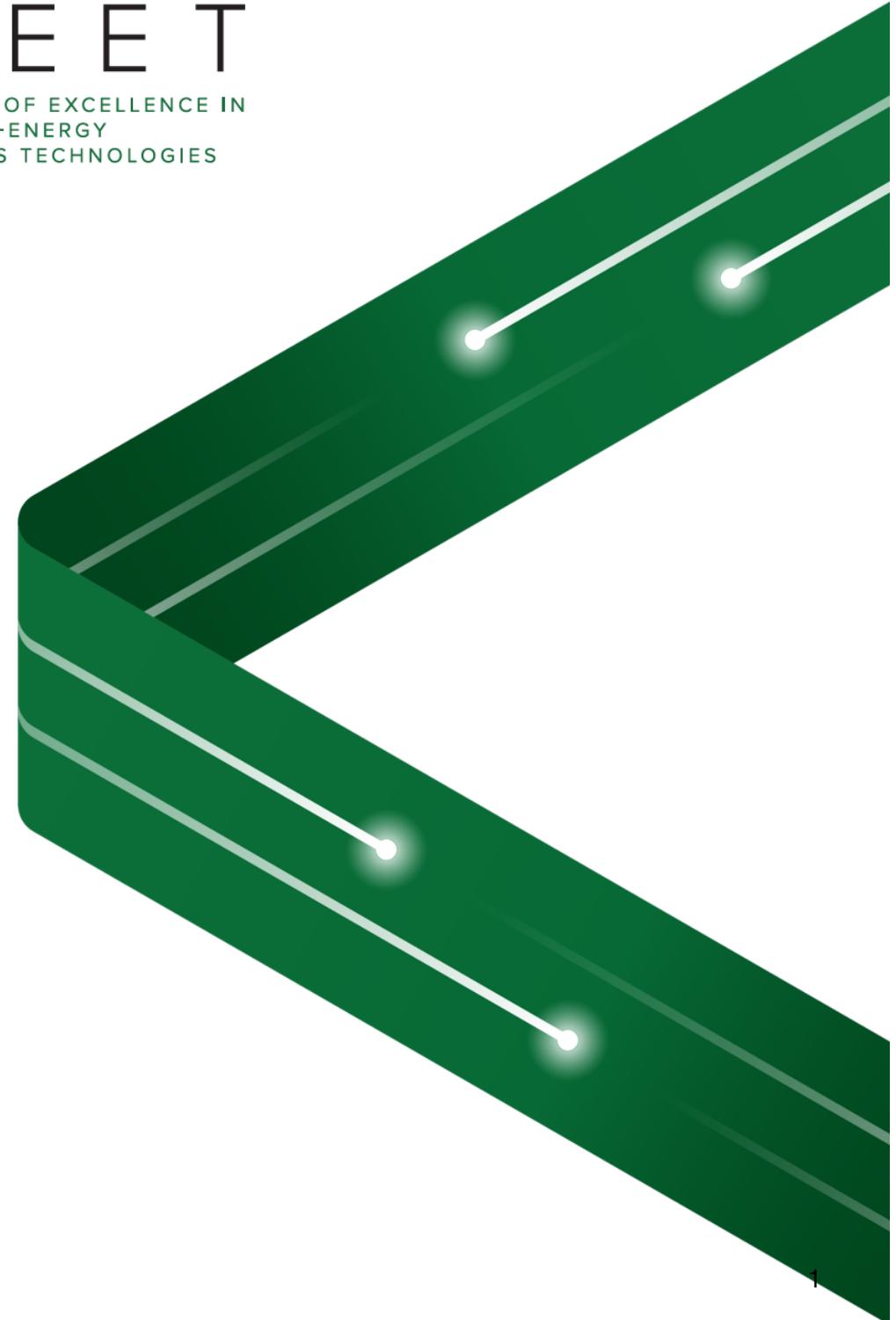
# Towards Efficient Spin Current Generation using Amorphous Materials

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Julie Karel

Department of Materials Science and  
Engineering, Monash University

FLEET and Materials Australia Seminar  
September 3, 2020



# About me



# Low Energy Electronics and Data Storage

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- Data is produced at a breathtaking rate
- By 2030, data centers could represent as much as 13% of total global electricity



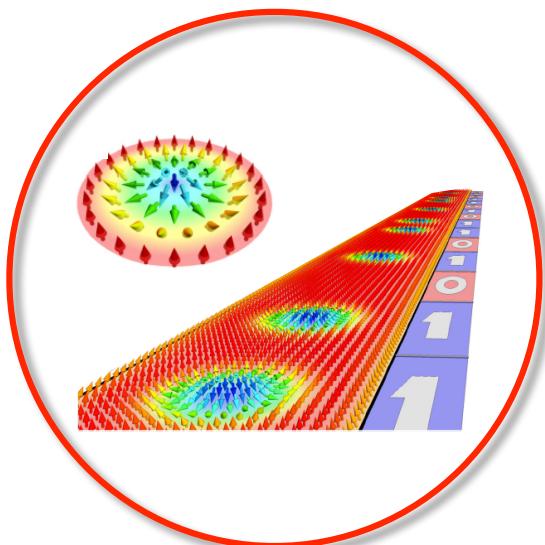
Image: [crn.com](https://crn.com)

<https://theconversation.com/bingeing-netflix-under-lockdown-heres-why-streaming-comes-at-a-cost-to-the-environment-143190>

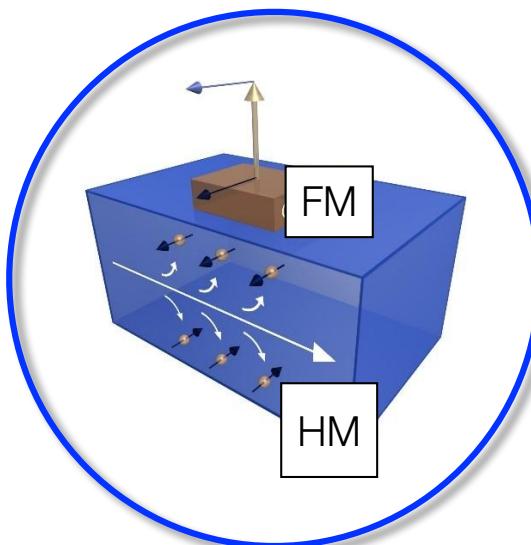
J.M.D. Coey, J. Phys.:Condens. Matt. (2014)

# Outline

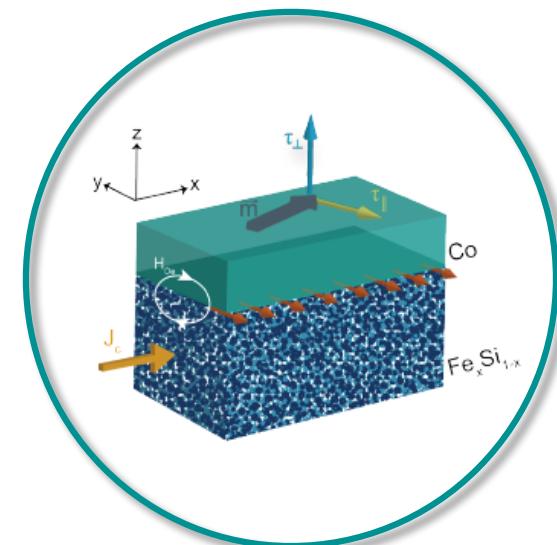
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Non-volatile memory  
and current  
challenges



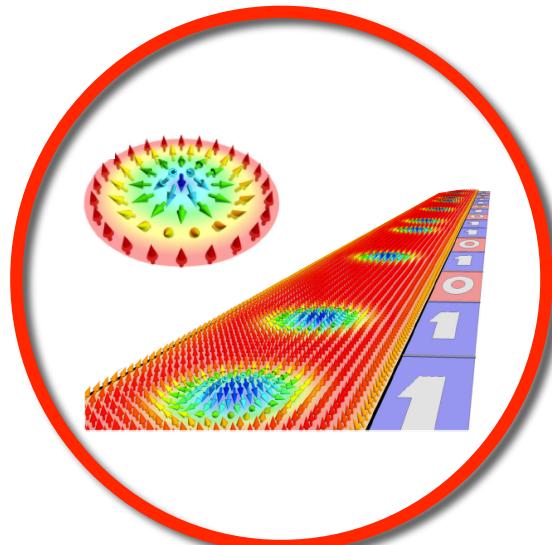
Methods for spin  
current generation



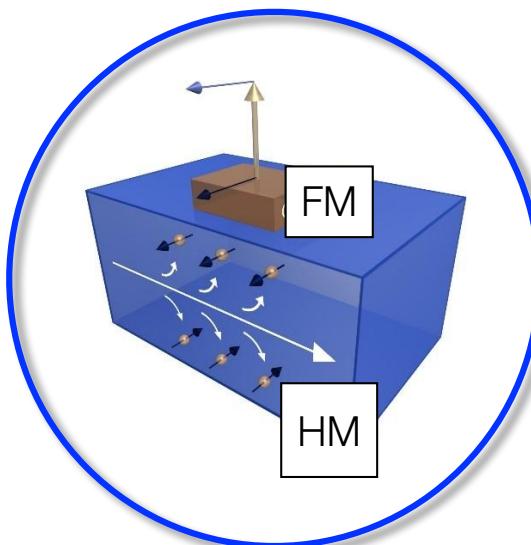
Using amorphous materials  
to create spin currents

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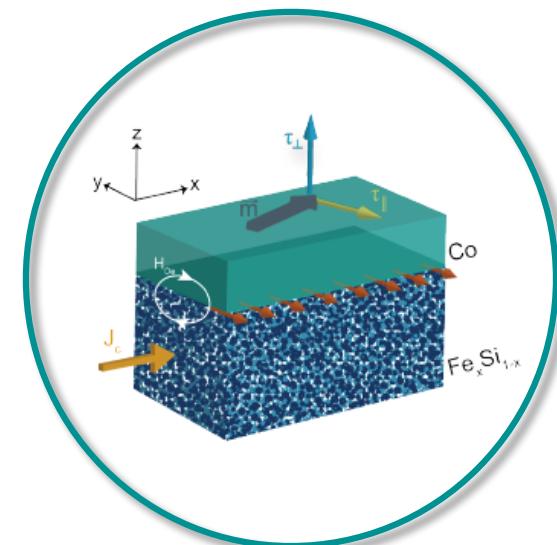
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Non-volatile memory  
and current  
challenges



Methods for spin  
current generation



Using amorphous materials  
to create spin currents

# Non-Volatile Memory

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- Data retained without power



Hard Disk Drive

Inexpensive ✓  
Slow ✗

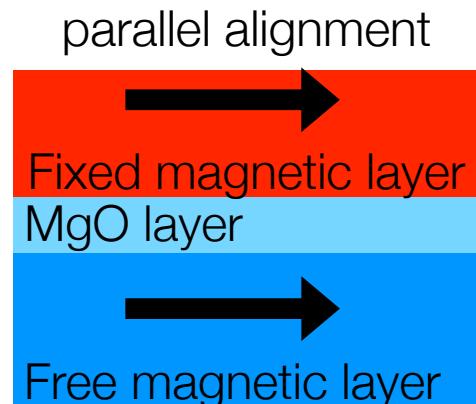
Solid State Drive

Fast ✓  
Low endurance ✗

# Emerging NVM: MRAM

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- Magnetoresistive random access memory
- Array of magnetic tunnel junctions

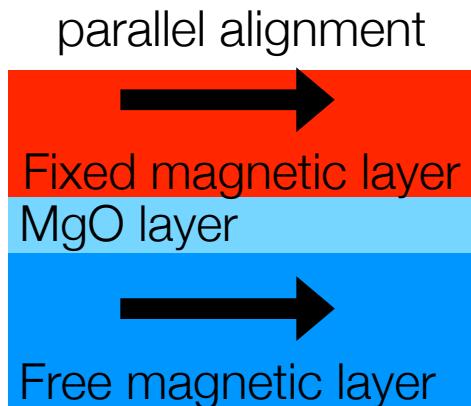


Resistance low  
“0”

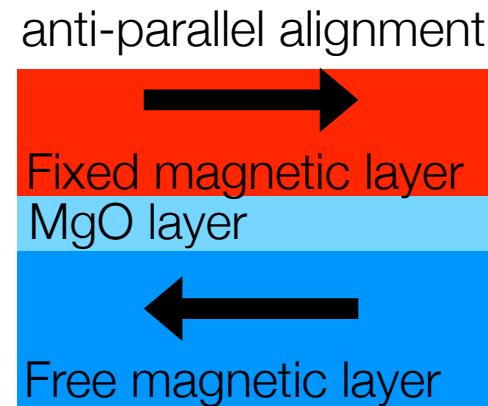
# Emerging NVM: MRAM

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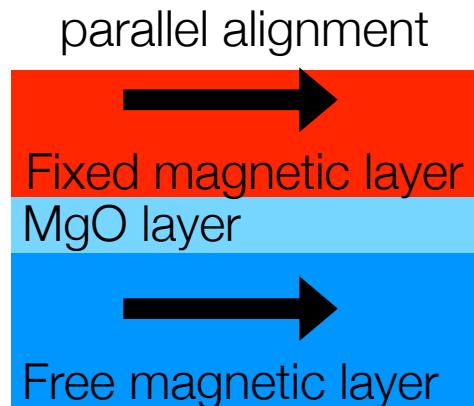


Resistance high  
“1”

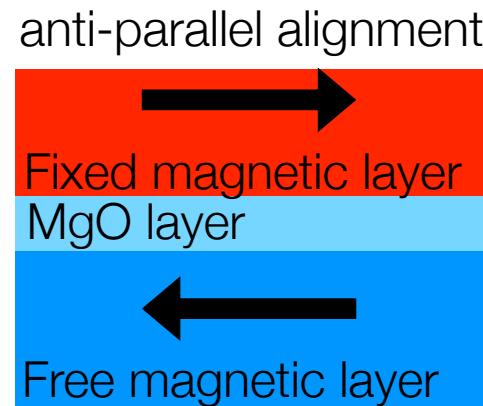
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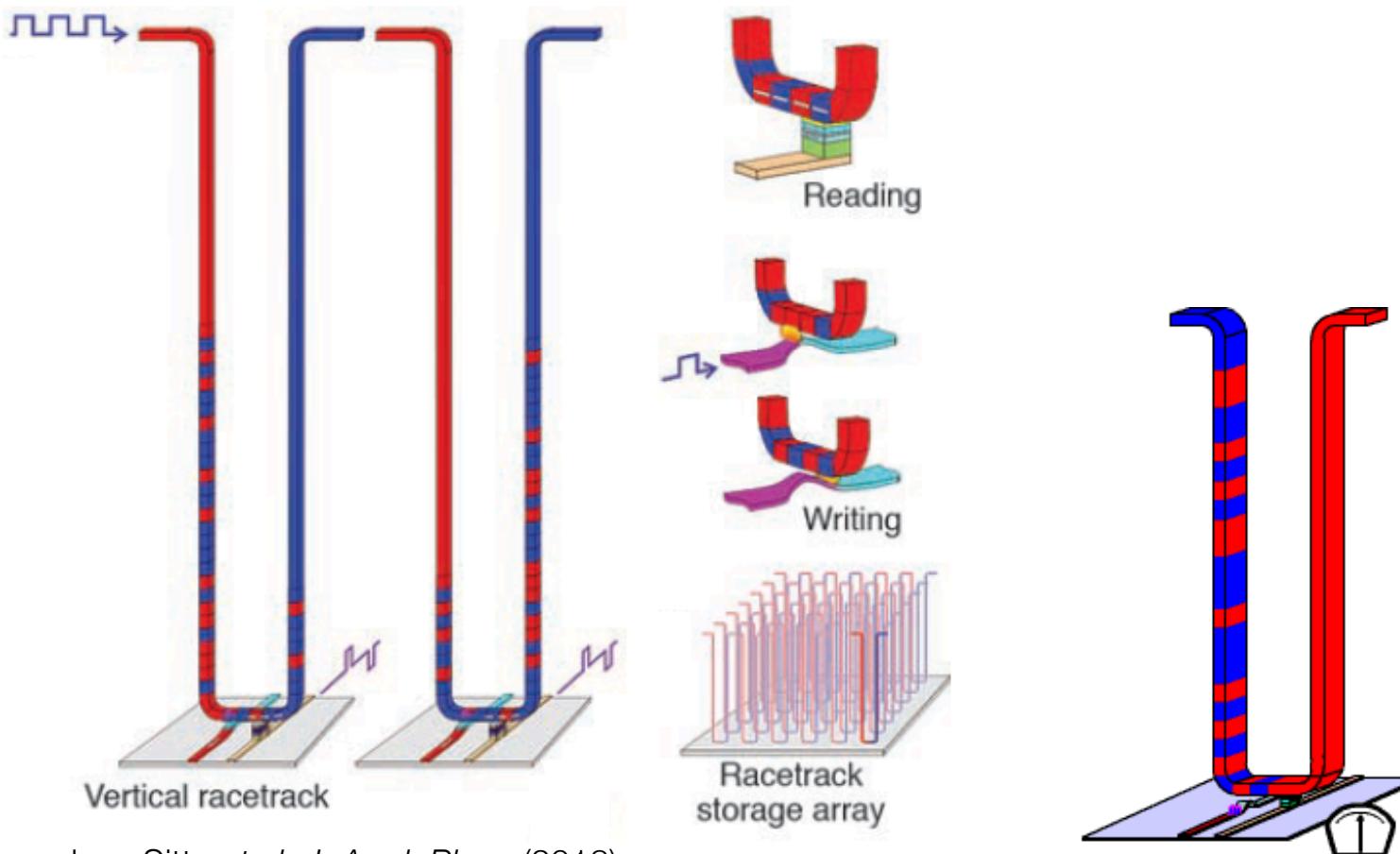


Resistance high  
“1”

- Need to switch free layer → spin orbit torque (SOT)

# Emerging NVM: Racetrack Memory

- Ferromagnetic nanowire
- Magnetic domain wall or Skyrミon



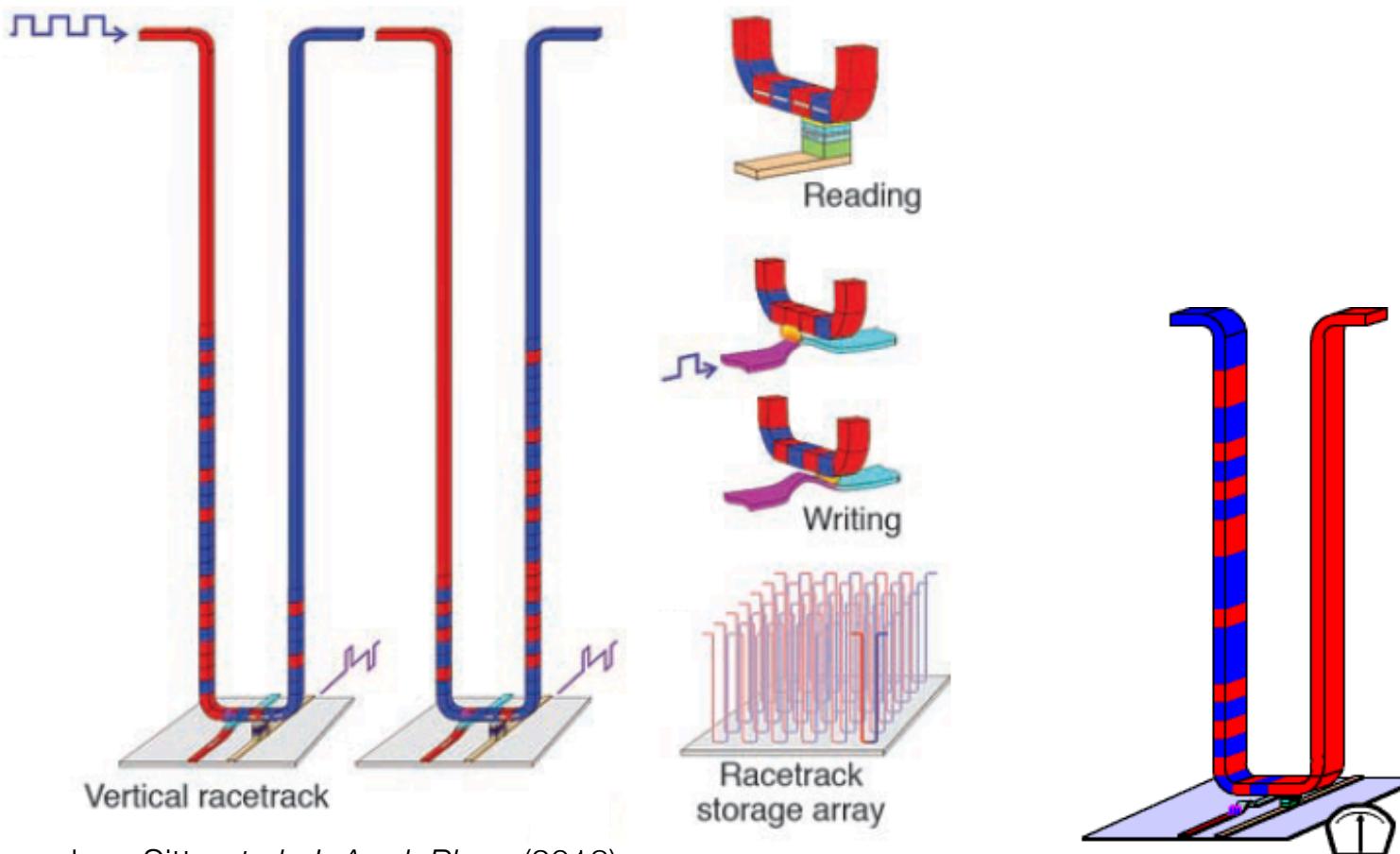
Everschorr-Sitte et al. *J. Appl. Phys.* (2018)

Parkin et al. *Science* (2008)

Vedmedenko et al. *J.Phys. D: Appl. Phys.* (2020)

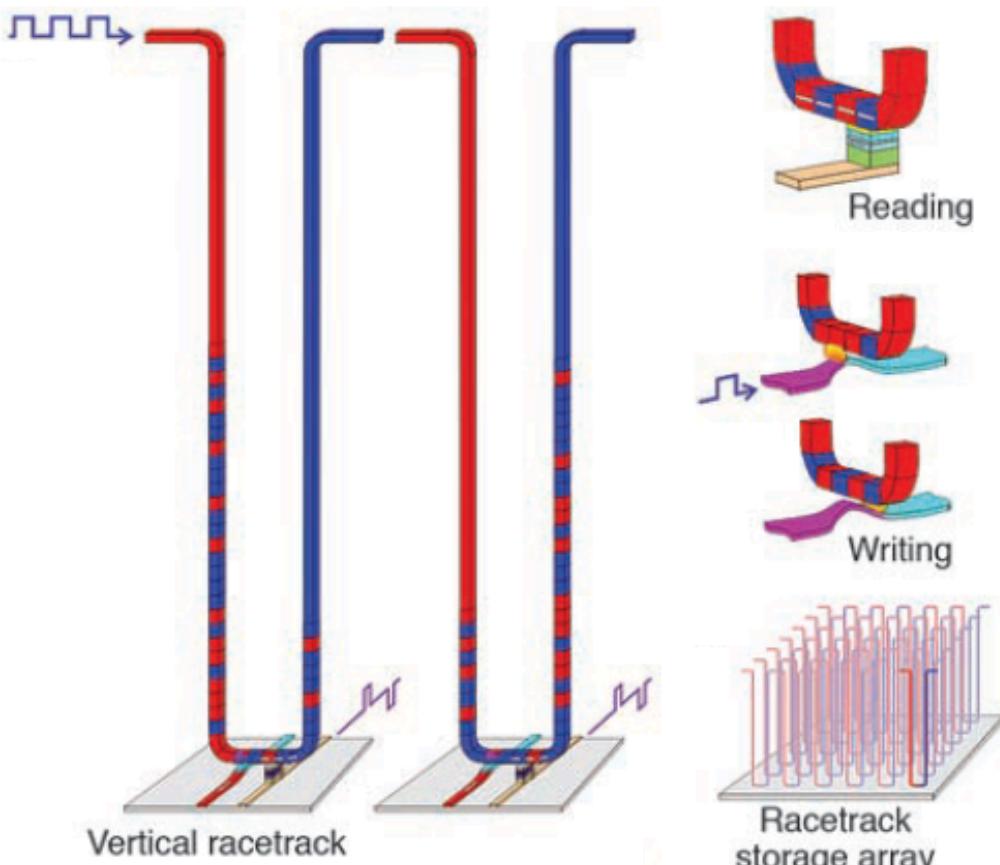
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- Ferromagnetic nanowire
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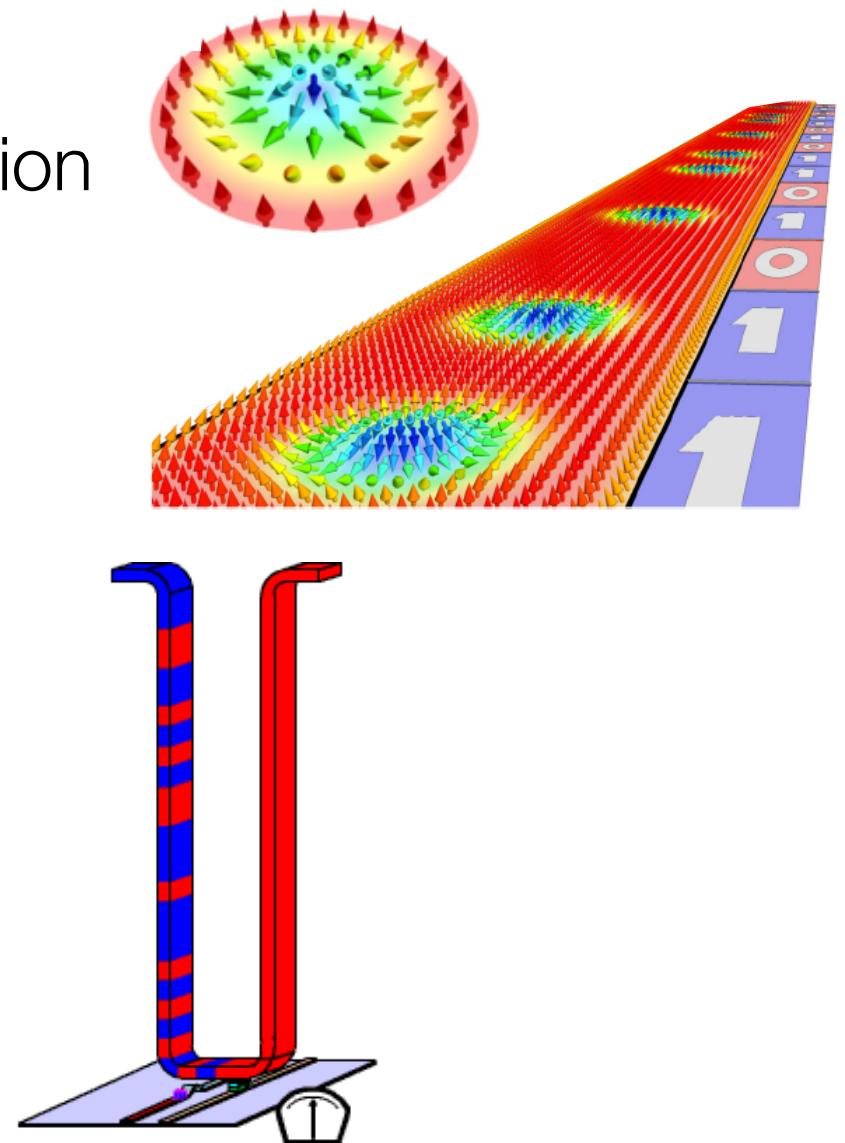


# Emerging NVM: Racetrack Memory

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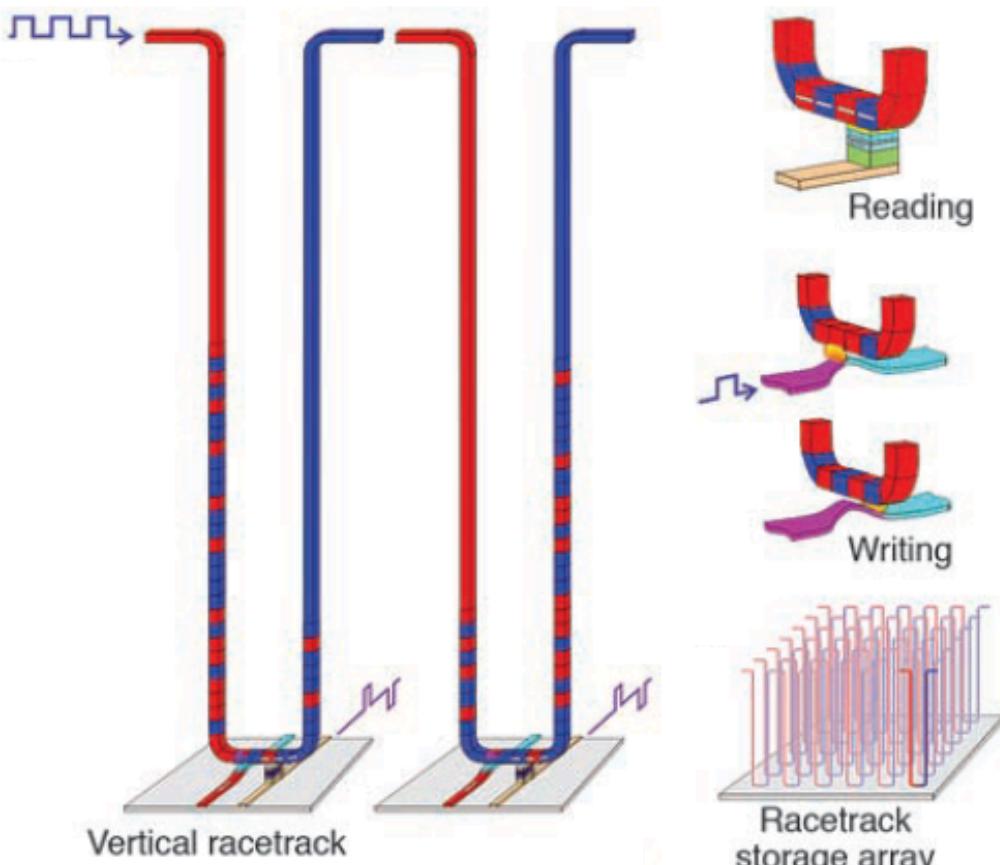
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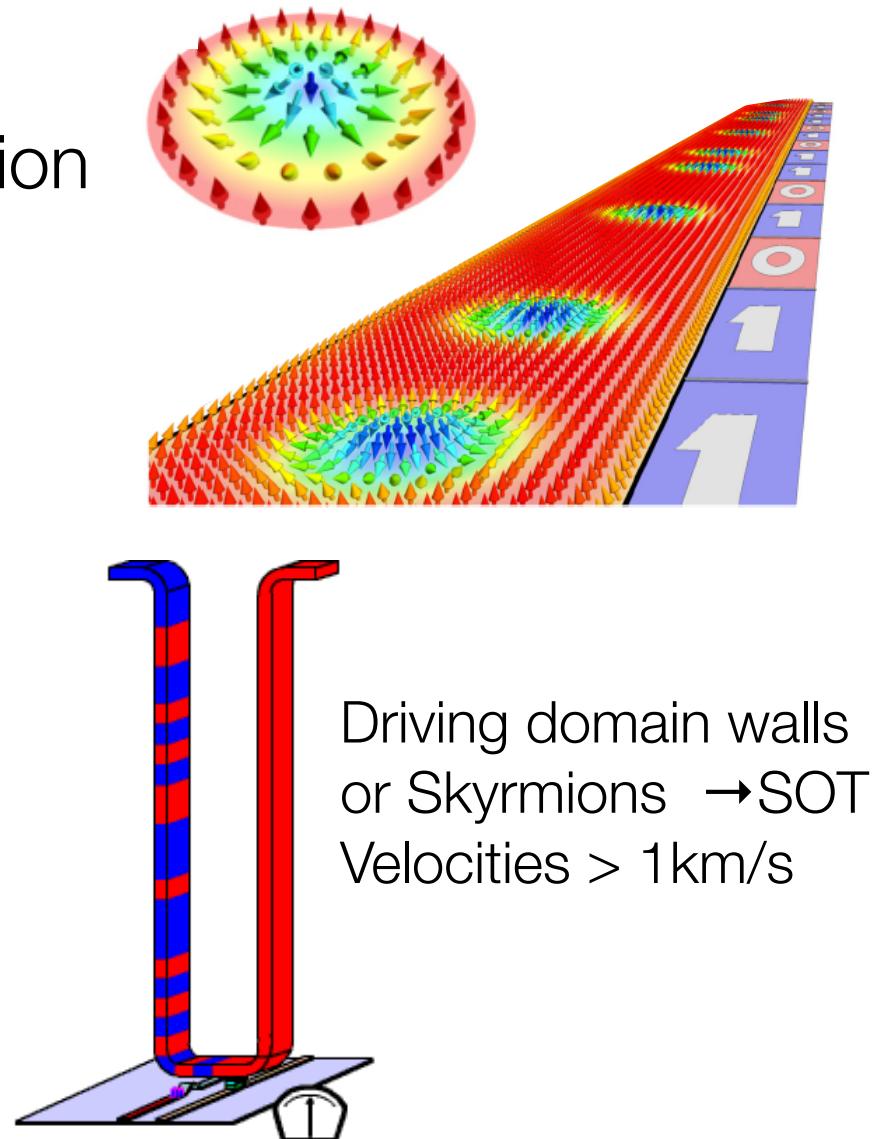
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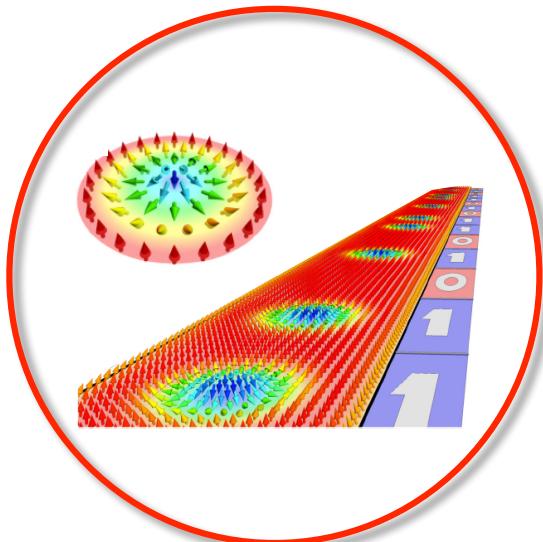
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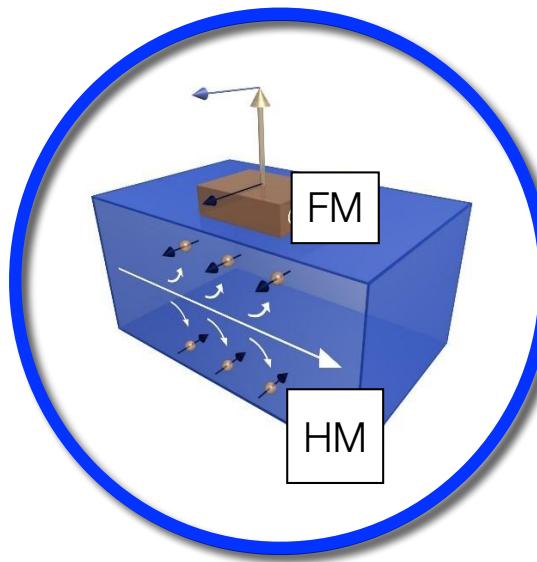
Vedmedenko et al. J.Phys. D: Appl. Phys. (2020)

# Outline

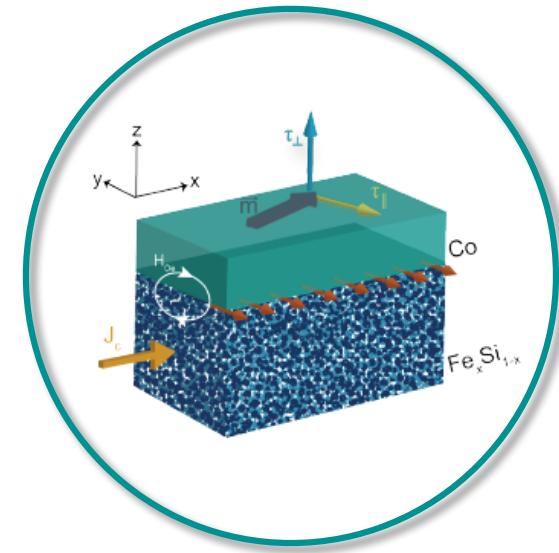
---



Non-volatile memory  
and current  
challenges



Methods for spin  
current generation

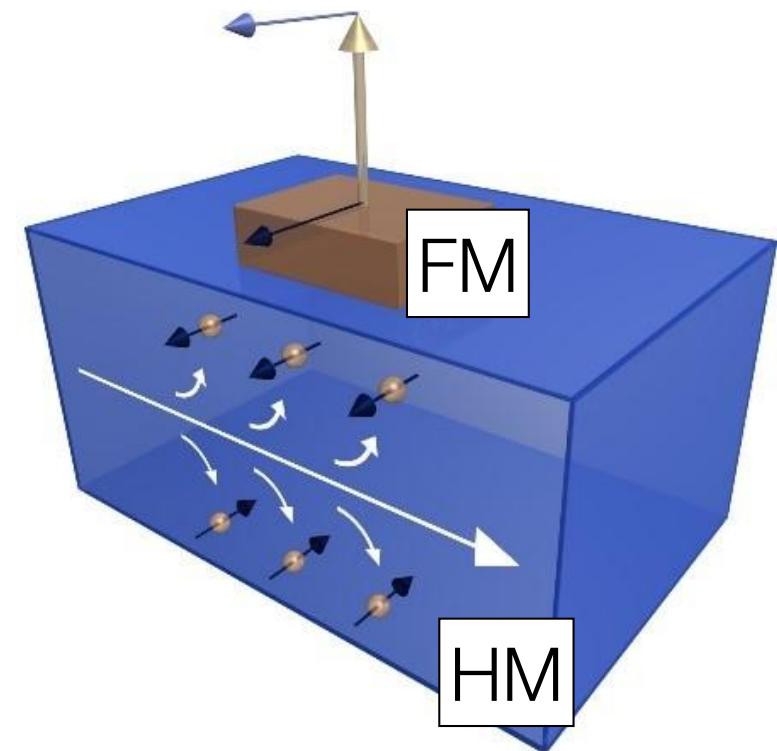


Using amorphous materials  
to create spin currents

# Spin Currents and Spin Orbit Torque

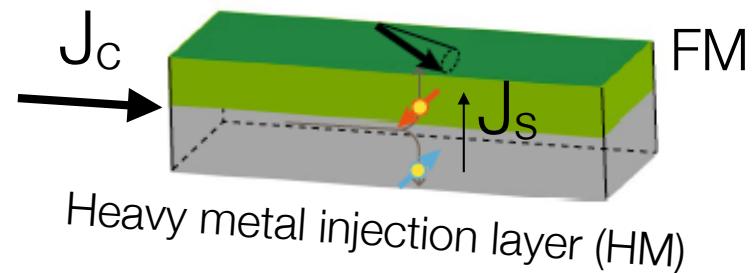
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- Transfer of angular momentum from orbital to spins
- Different than spin transfer torque
- Charge to spin current conversion
  - Current induced switching



# Charge to Spin Current Conversion

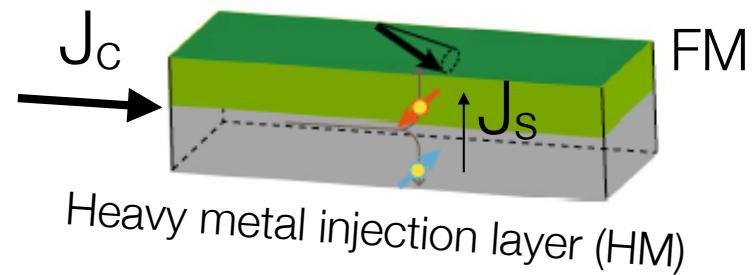
- Non-magnets



# Charge to Spin Current Conversion

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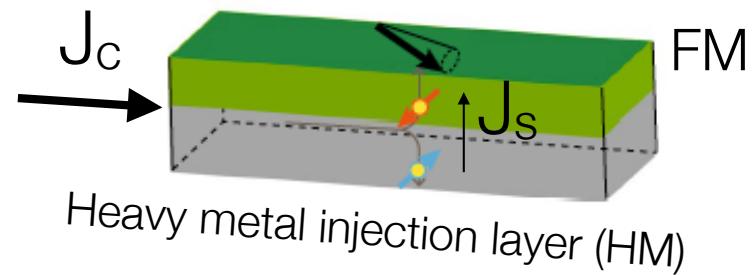
- Non-magnets
  - Spin Hall effect



# Charge to Spin Current Conversion

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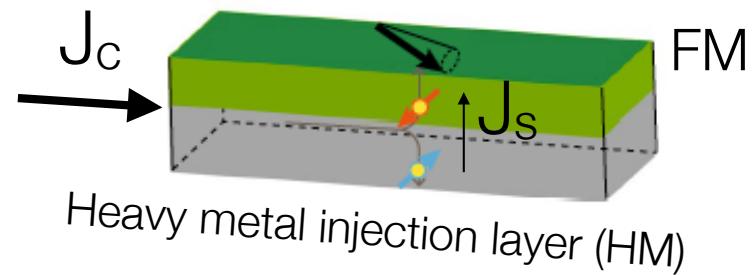
- Non-magnets
  - Spin Hall effect
  - Rashba-Edelstein effect



# Charge to Spin Current Conversion

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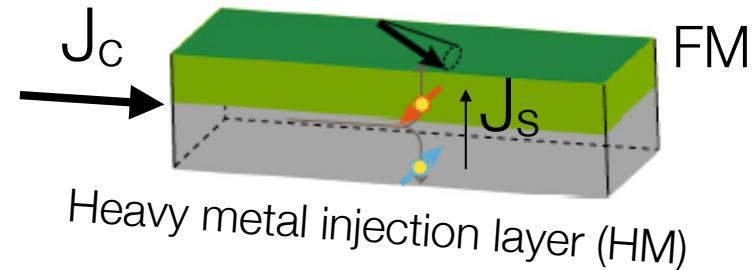
- Non-magnets
  - Spin Hall effect
  - Rashba-Edelstein effect
  - Spin momentum locking in TI



# Charge to Spin Current Conversion

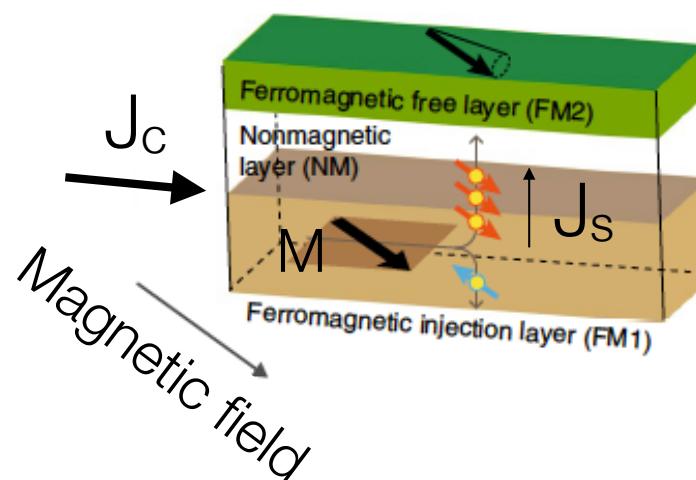
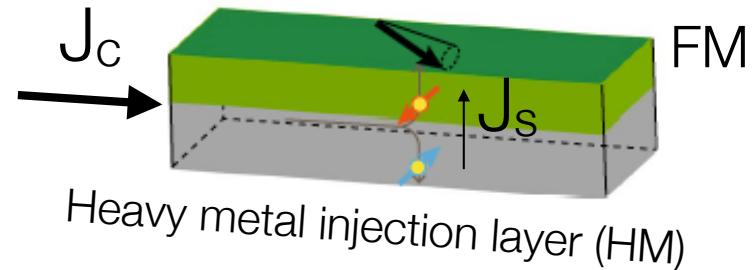
---

- Non-magnets
  - Spin Hall effect
  - Rashba-Edelstein effect
  - Spin momentum locking in TI
- Ferromagnets
  - Anomalous Hall effect



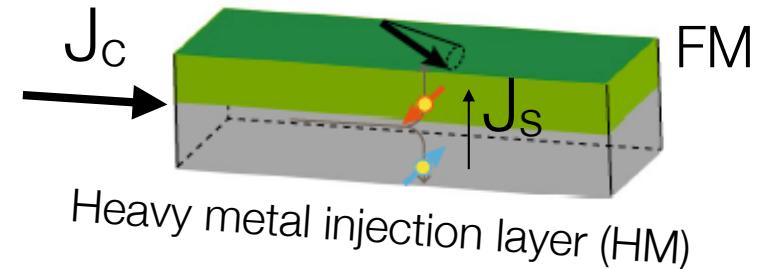
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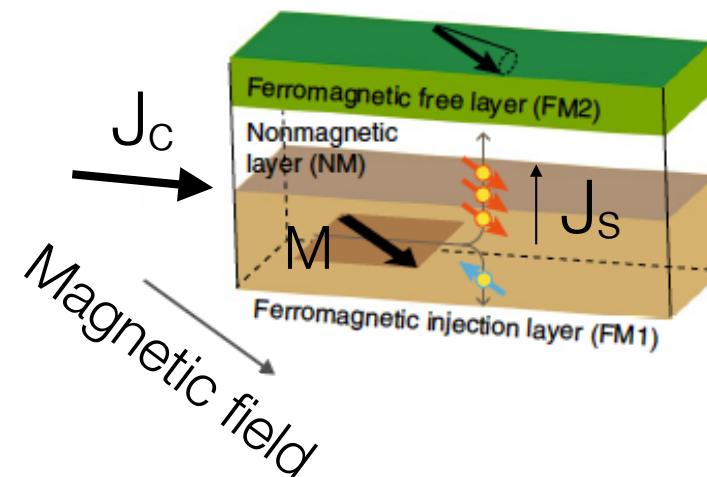


# Charge to Spin Current Conversion

- Non-magnets
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  - Rashba-Edelstein effect
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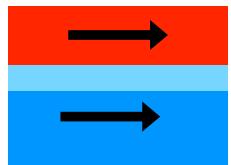


$$\xi = \frac{\text{spin current}}{\text{charge current}}$$

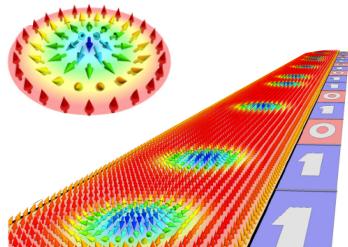


# Materials and Challenges

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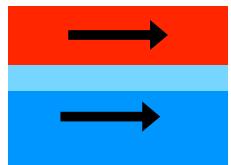
SOT-MRAM



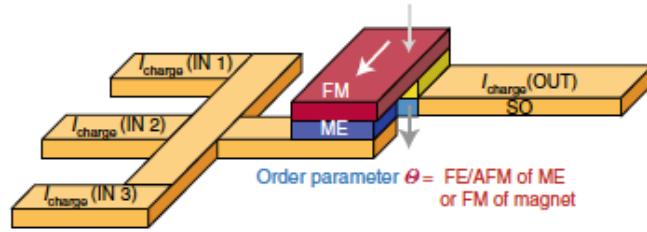
Racetrack  
Memory

# Materials and Challenges

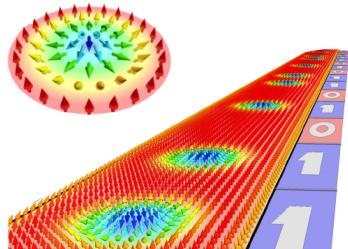
---



SOT-MRAM



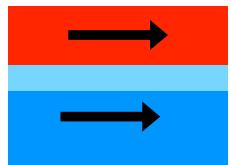
Spin Logic



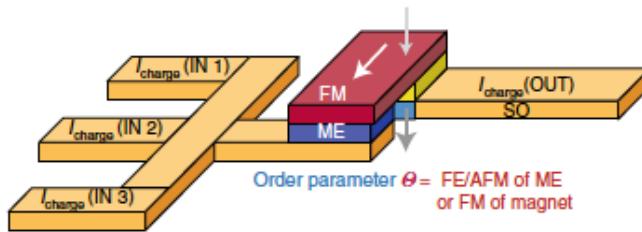
Racetrack  
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# Materials and Challenges

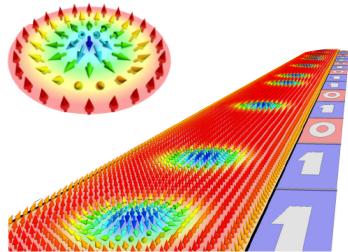
---



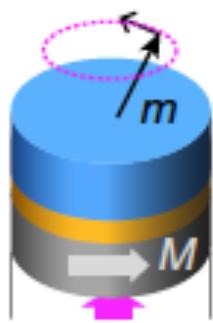
SOT-MRAM



Spin Logic

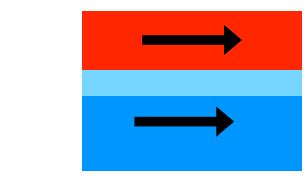


Racetrack  
Memory

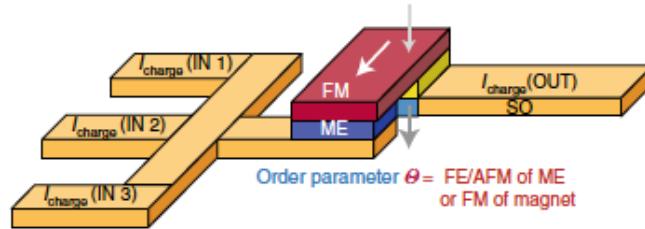


Spin Torque Nano-  
oscillators

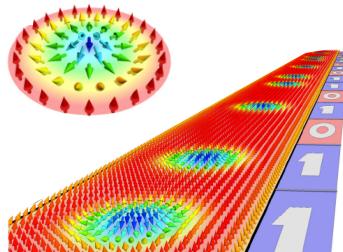
# Materials and Challenges



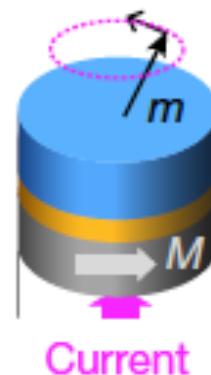
SOT-MRAM



Spin Logic



Racetrack  
Memory

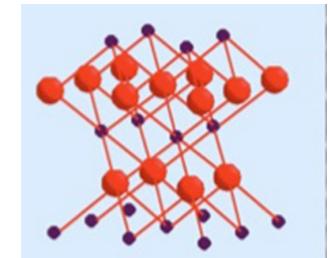


Spin Torque Nano-  
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## Materials

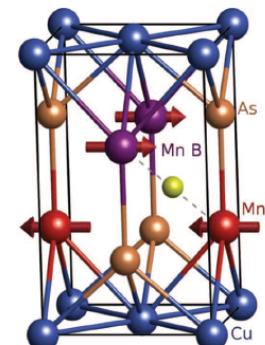
### Topological Insulators

$\text{Bi}_2\text{Se}_3$ ,  $\text{Bi}_x\text{Se}_{1-x}$ ,  $\text{Bi}_{1-x}\text{Sb}_x$



### Metals

Pt, W, Ta, Au, Ag, Dy....

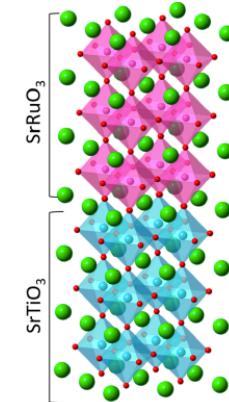


### Antiferromagnets

$\text{CuMnAs}$ ,  $\text{Mn}_2\text{Au}$ ,  $\text{PtMn}$ ,  
 $\text{IrMn}$ ,  $\text{NiO}$

### Oxides

$\text{SrRuO}_3$ ,  $\text{SrIrO}_3$ ,  
 $\text{IrO}_2$



### Ferromagnets

$\text{CoFeB}$ ,  $(\text{Fe}_{1-x}\text{Mn}_x)_{0.6}\text{Pt}_{0.4}$ ,  
 $\text{NiFe}$

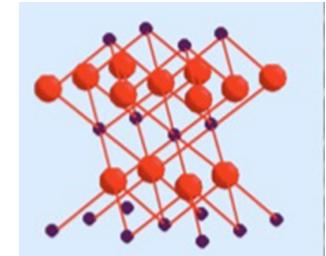
# Materials and Challenges

- Increasing  $\xi$
- High resistivity (not compatible with low voltage devices)
- CMOS compatibility
- Air sensitivity
- Cost

## Materials

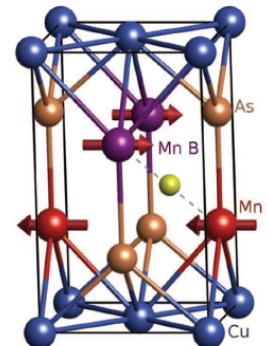
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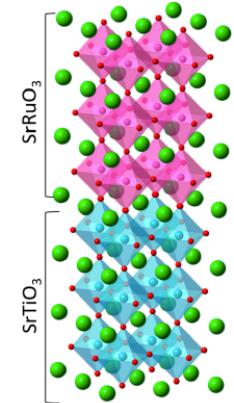


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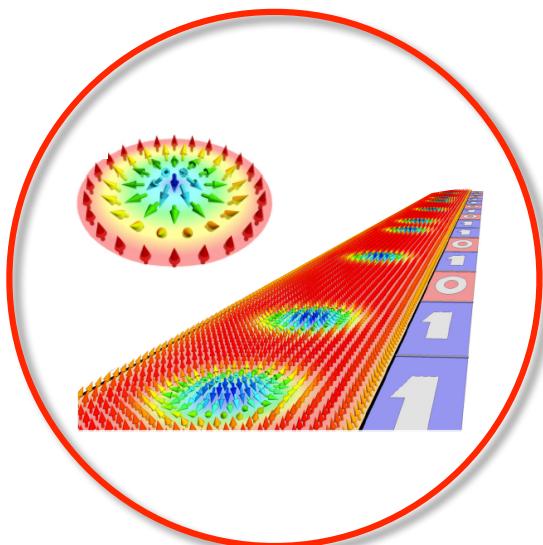


### Ferromagnets

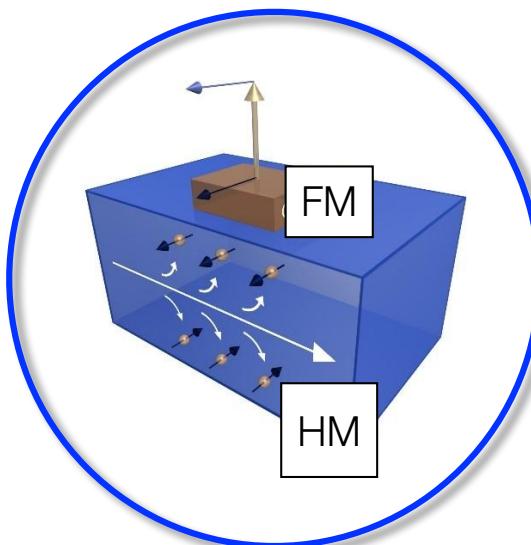
$\text{CoFeB}$ ,  $(\text{Fe}_{1-x}\text{Mn}_x)_{0.6}\text{Pt}_{0.4}$ ,  
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# Outline

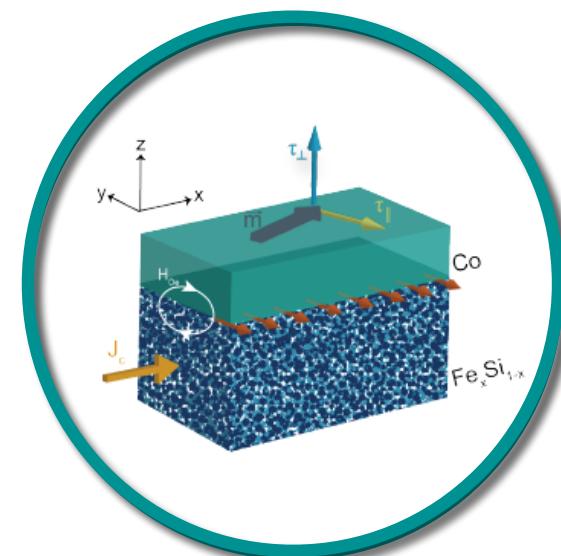
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Non-volatile memory  
and current  
challenges



Methods for spin  
current generation



Using amorphous materials  
to create spin currents

Ferromagnets  
Non-magnetic

# Motivation

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- Defect tolerant, low cost, CMOS compatible
- SHE, AHE, TI → topology in electronic structure, non-zero Berry curvature

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PRL 118, 236402 (2017)

PHYSICAL REVIEW LETTERS

week ending  
9 JUNE 2017



## Topological Insulators in Amorphous Systems

Adhip Agarwala and Vijay B. Shenoy\*

*Department of Physics, Indian Institute of Science, Bangalore 560012, India*

(Received 31 March 2017; published 8 June 2017)

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PHYSICAL REVIEW LETTERS 123, 076401 (2019)

Editors' Suggestion

## Topological Amorphous Metals

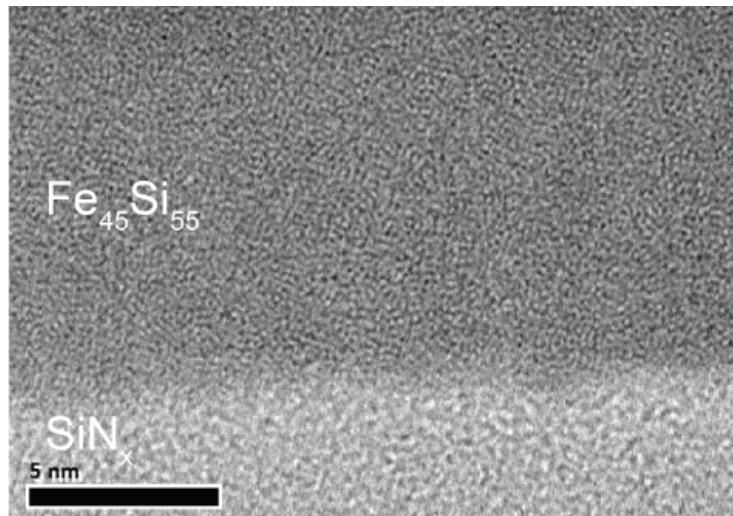
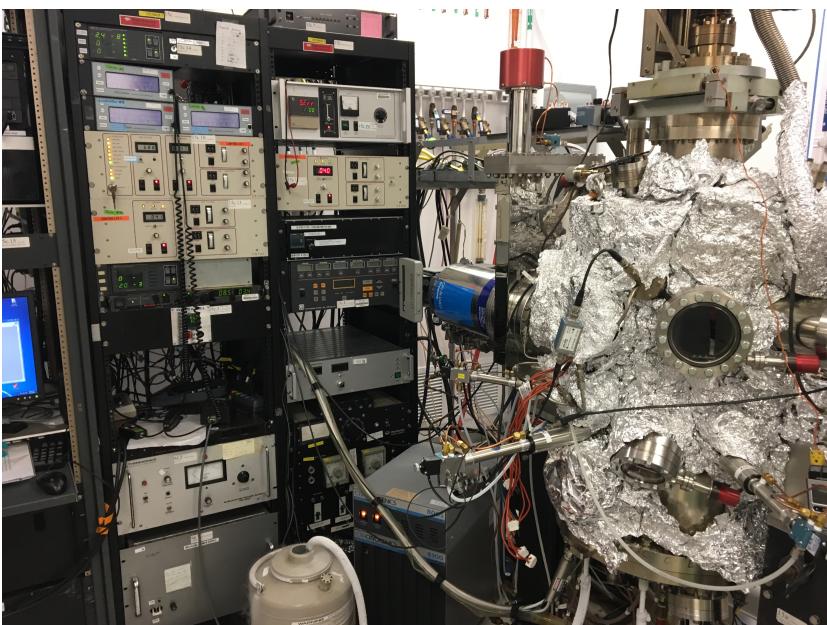
Yan-Bin Yang,<sup>1</sup> Tao Qin,<sup>2</sup> Dong-Ling Deng,<sup>1</sup> L.-M. Duan,<sup>1</sup> and Yong Xu<sup>1\*</sup>

<sup>1</sup>*Center for Quantum Information, IIIS, Tsinghua University, Beijing 100084, People's Republic of China*

<sup>2</sup>*Department of Physics, School of Physics and Materials Science, Anhui University, Hefei, Anhui Province 230601, People's Republic of China*

# Thin Film Experimental Procedure

Amorphous  $\text{Fe}_x\text{Si}_{1-x}$ ,  $\text{Fe}_x\text{Ge}_{1-x}$ ,  
 $\text{Fe}_{1-y}\text{Co}_y\text{Si}_{1-x}$ ,  $\text{Co}_x\text{Si}_{1-x}$ ,  $\text{Co}_x\text{Ge}_{1-x}$   
( $x=0.43-0.72$ ;  $y=0-0.3$ ) thin films  
at room temperature on  
amorphous  $\text{SiN}_x$  substrates

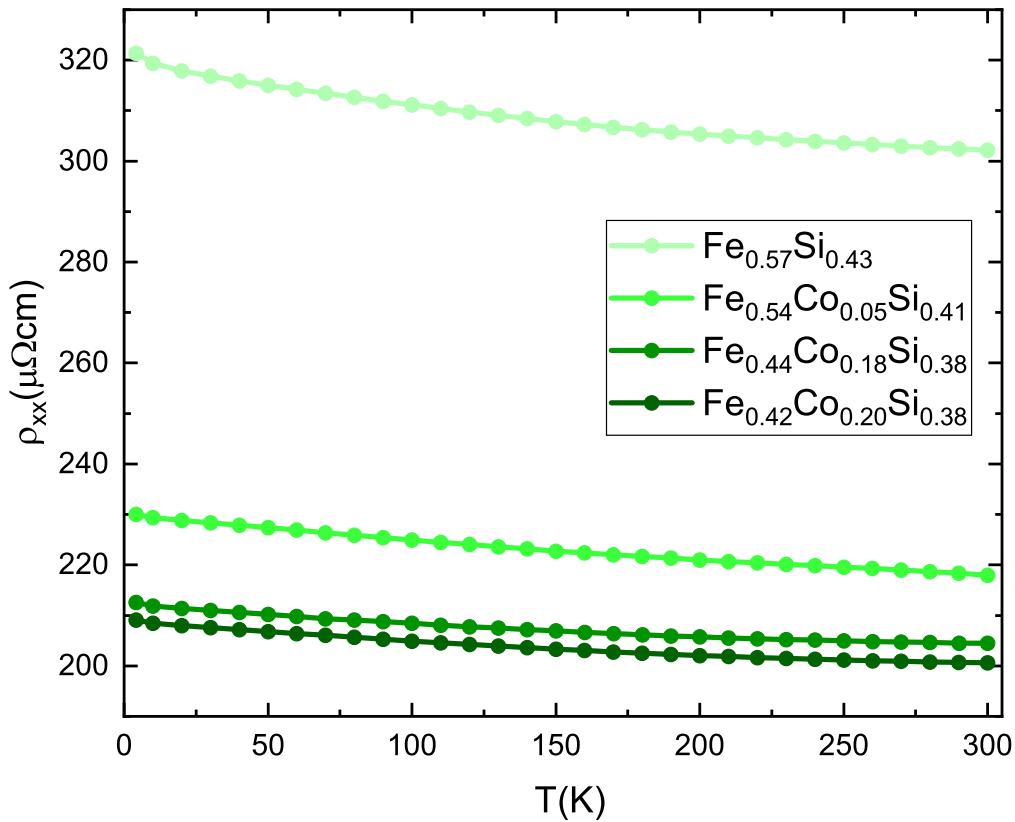


Characterization:  
CEMS  
XAFS  
XAS/XMCD  
SQUID magnetometry  
HAXPES  
PCAR

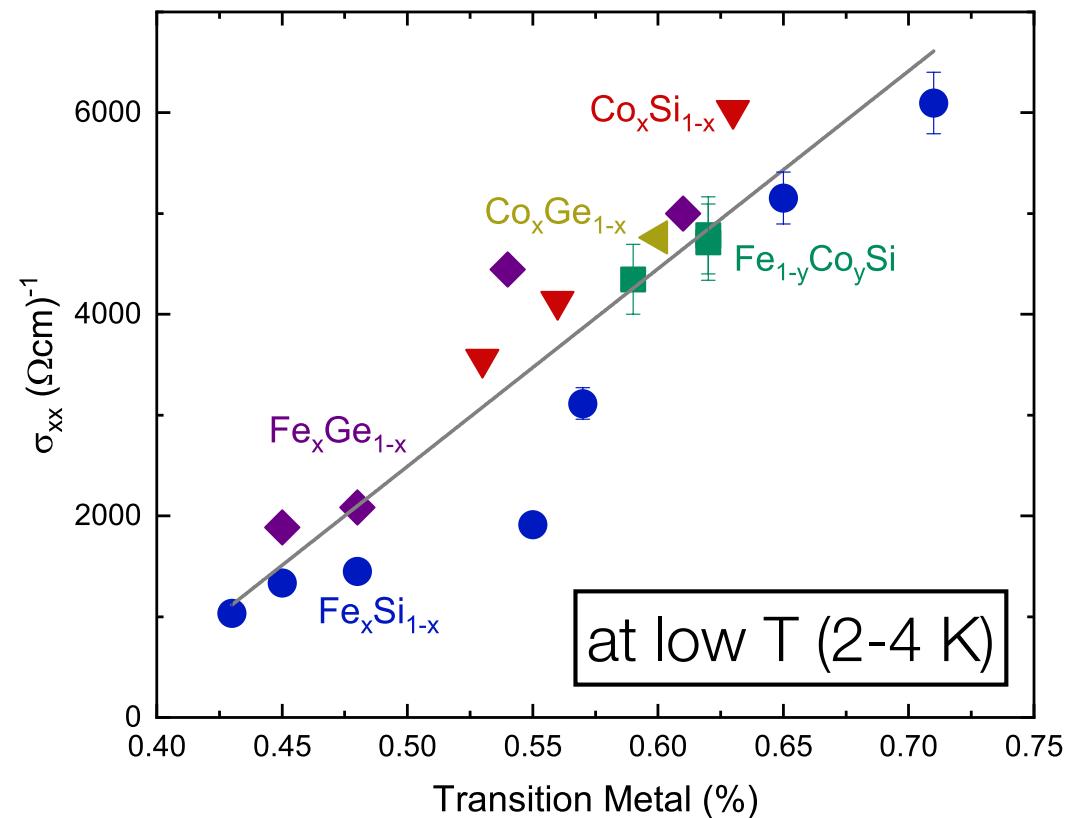
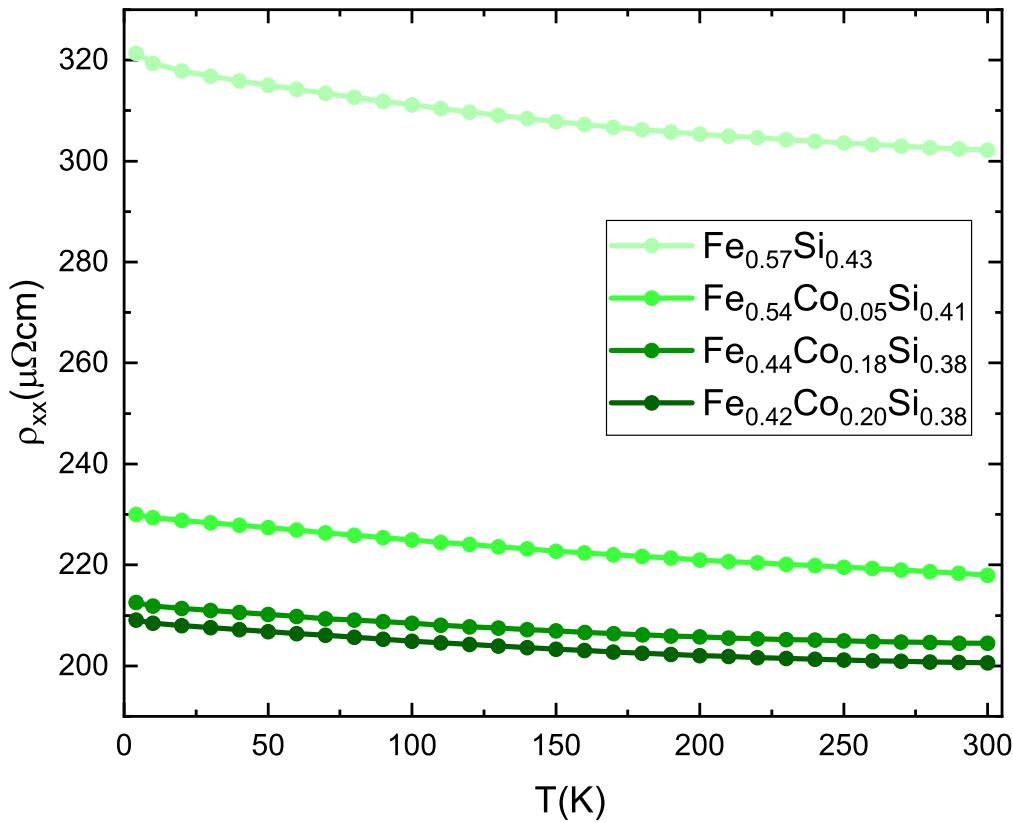
Electronic and magnetotransport

# Electronic Transport

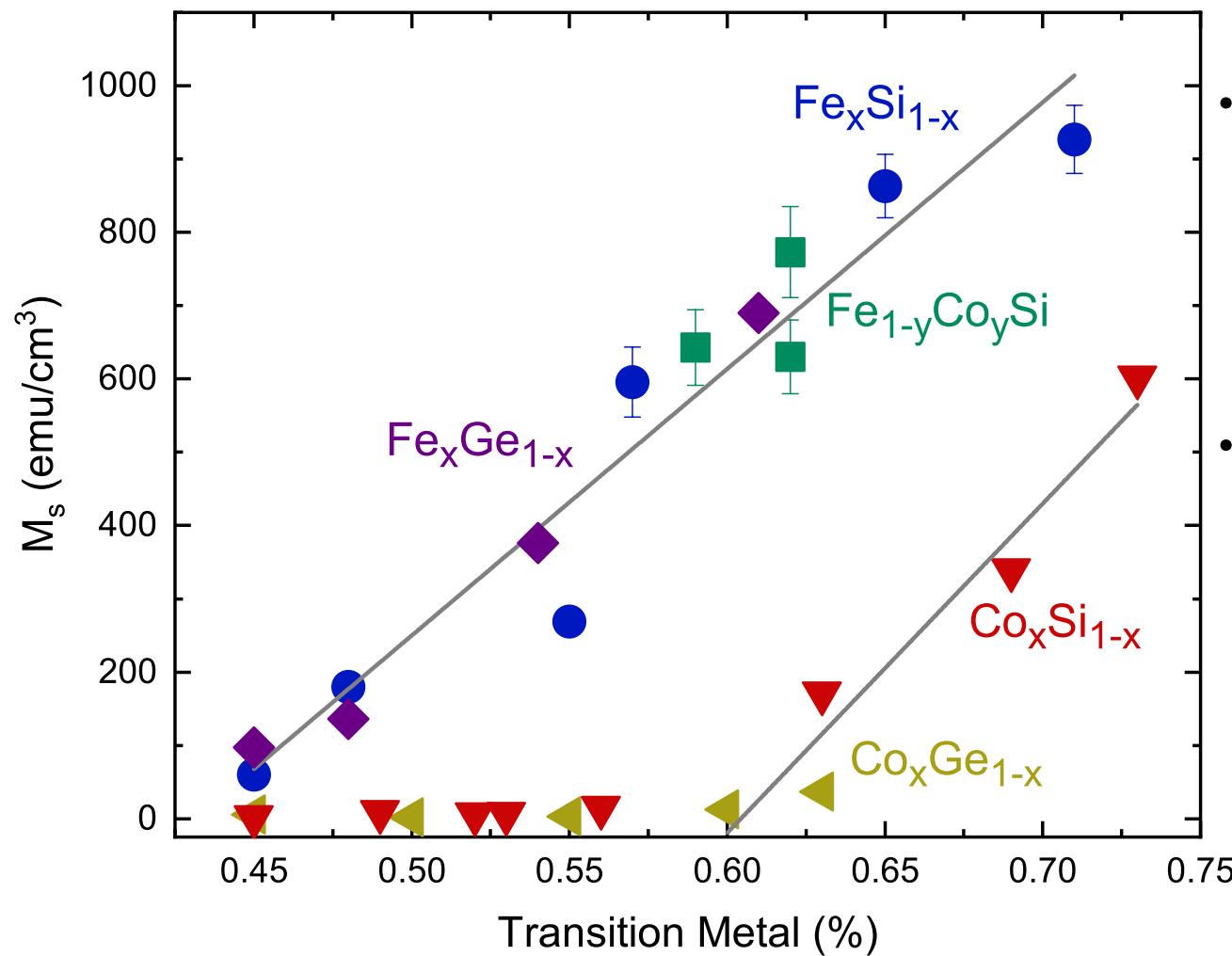
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# Electronic Transport

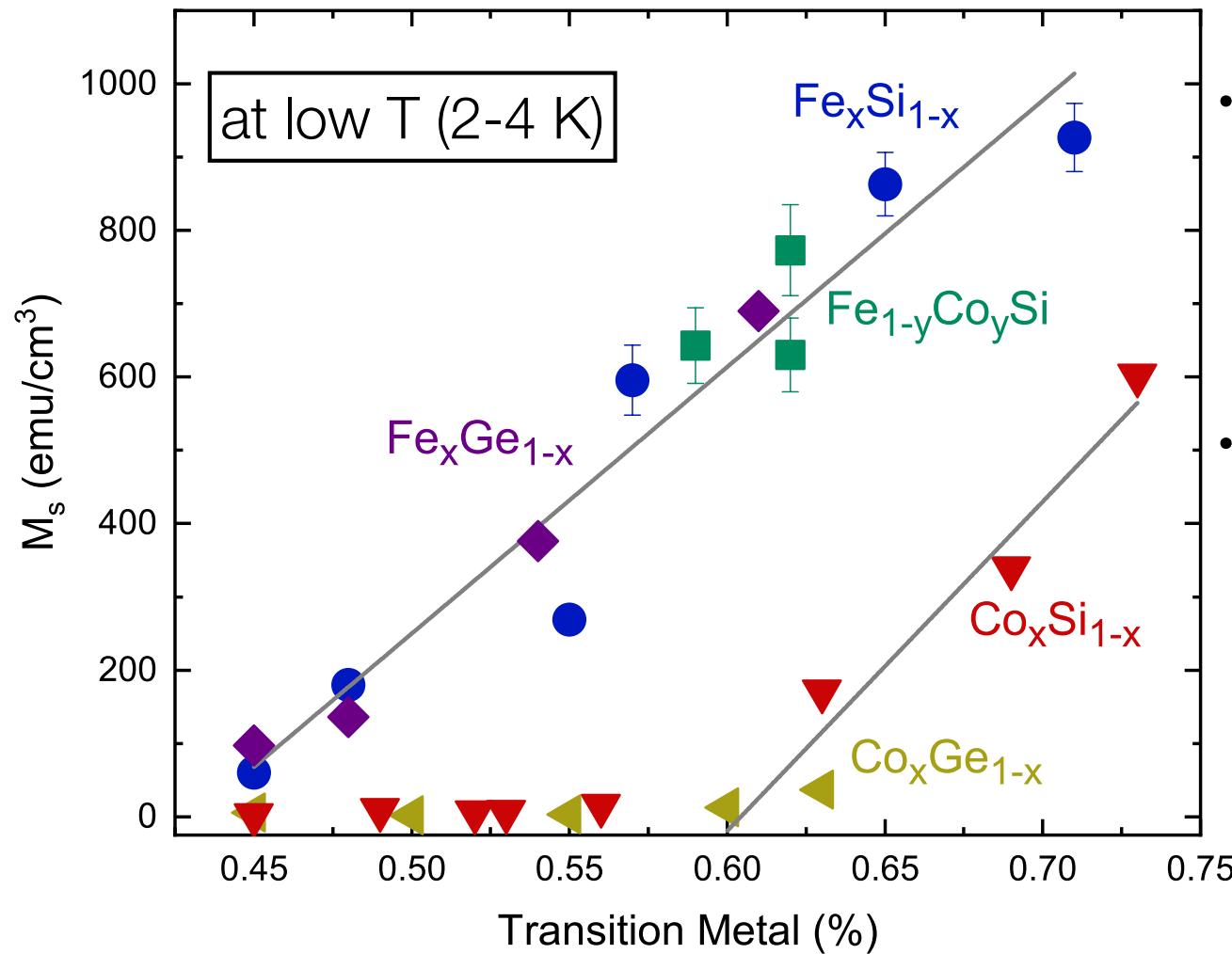


# Saturation Magnetization



- For Fe-based and Co-based ( $>0.60$ ) samples, FM at low T
- For Fe-based ( $>0.55$ ), FM at RT

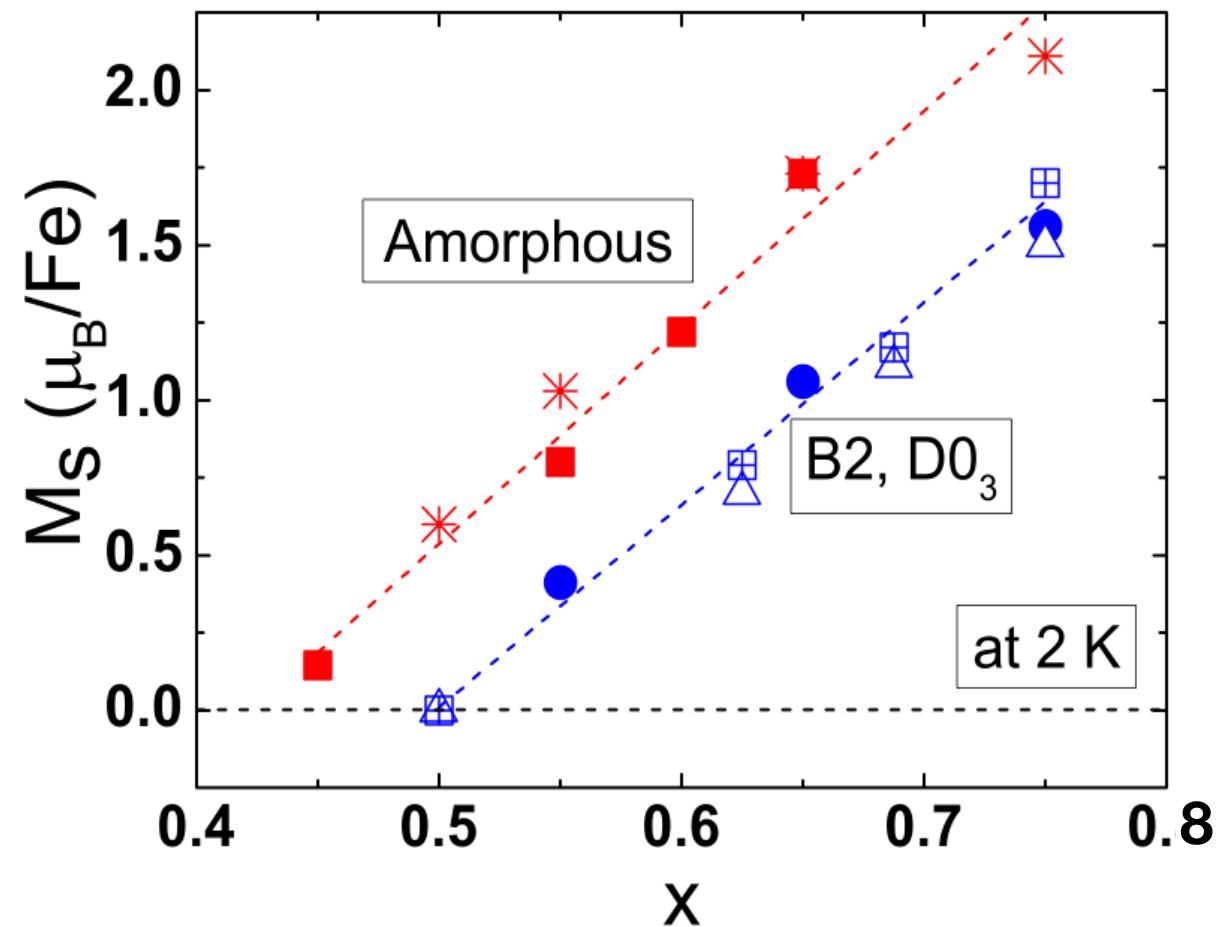
# Saturation Magnetization



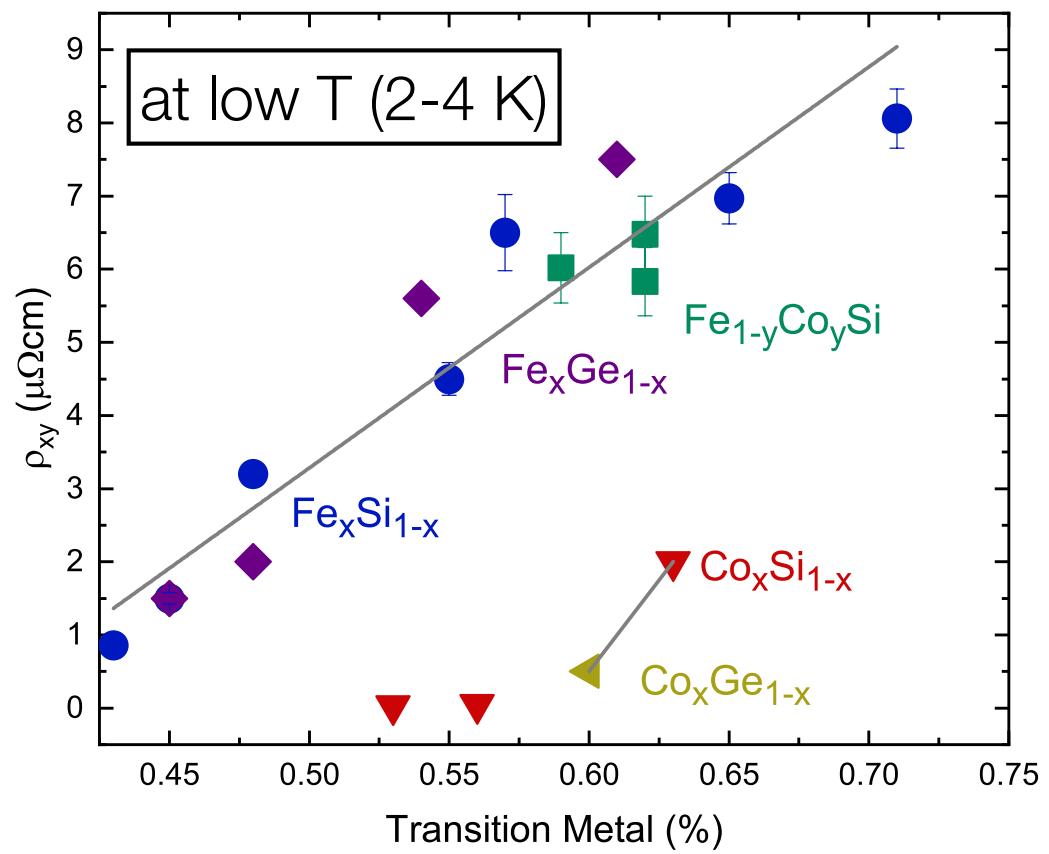
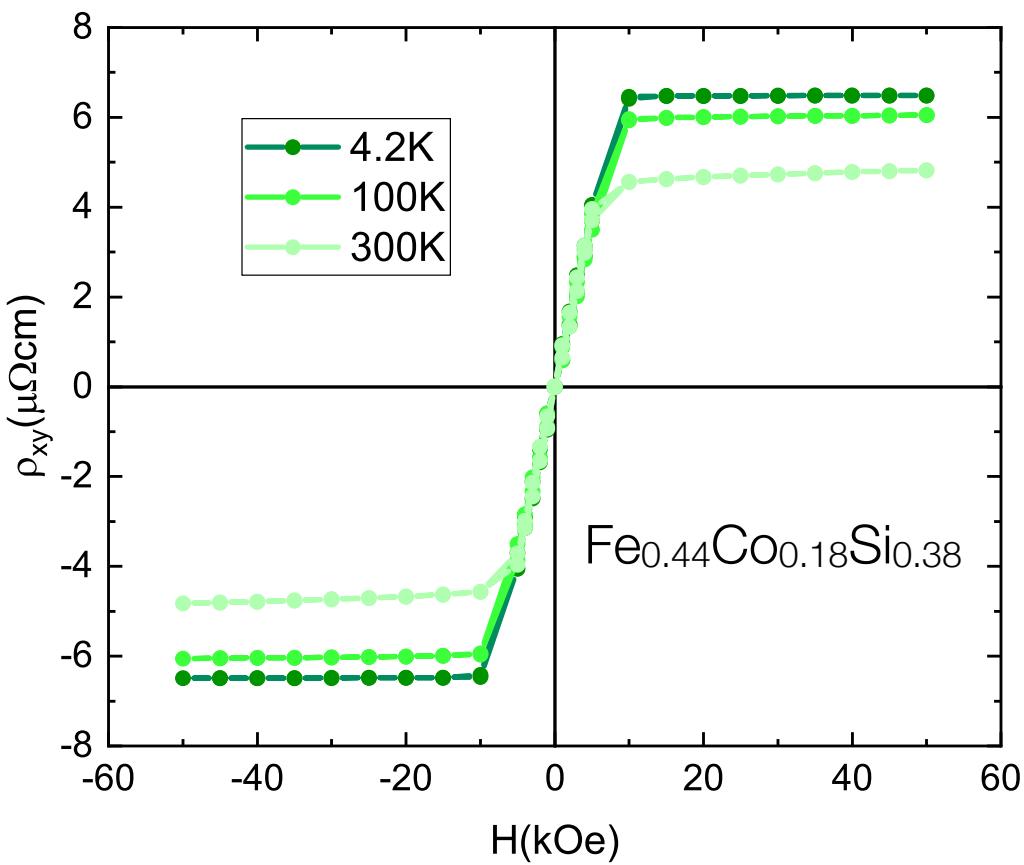
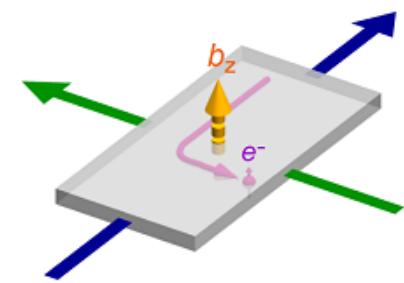
- For Fe-based and Co-based (>0.60) samples, FM at low T
- For Fe-based (>0.55), FM at RT

# Magnetic Moment in $\text{Fe}_x\text{Si}_{1-x}$ Thin Films

- Enhanced magnetic moment in amorphous films
- Reduction in Fe-Si first NN pairs → reduced p-d hybridization

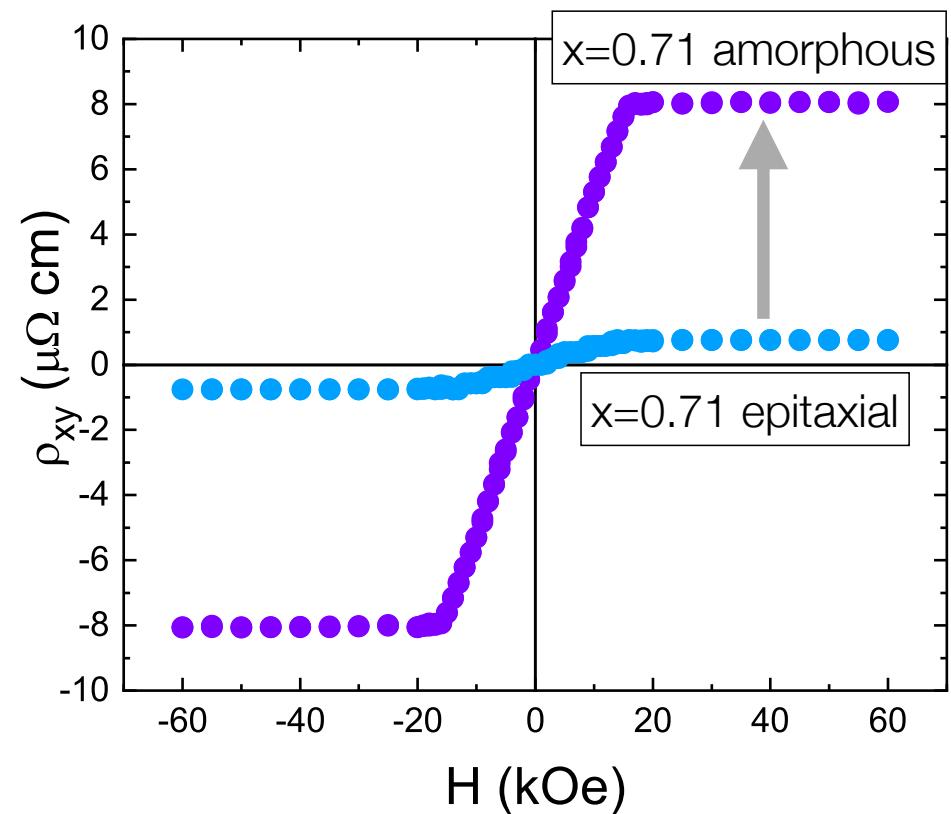


# Anomalous Hall Effect



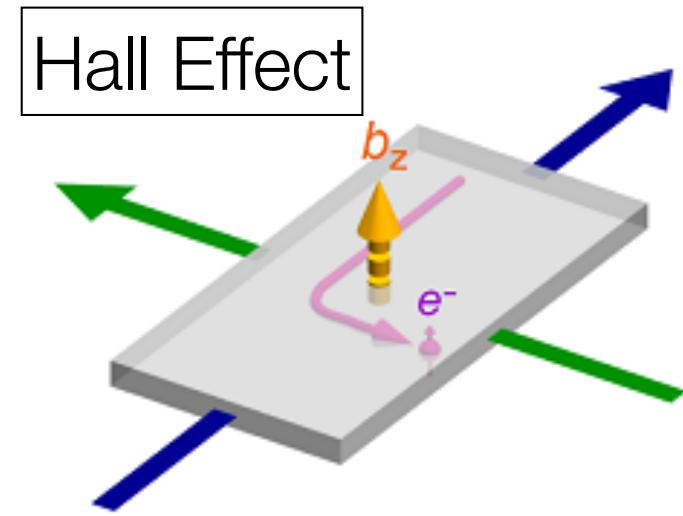
# Amorphous Materials with Large AHE

- Large AHE in amorphous  $\text{Fe}_x\text{Si}_{1-x}$  ( $x=0.43-0.71$ ) in comparison to crystalline



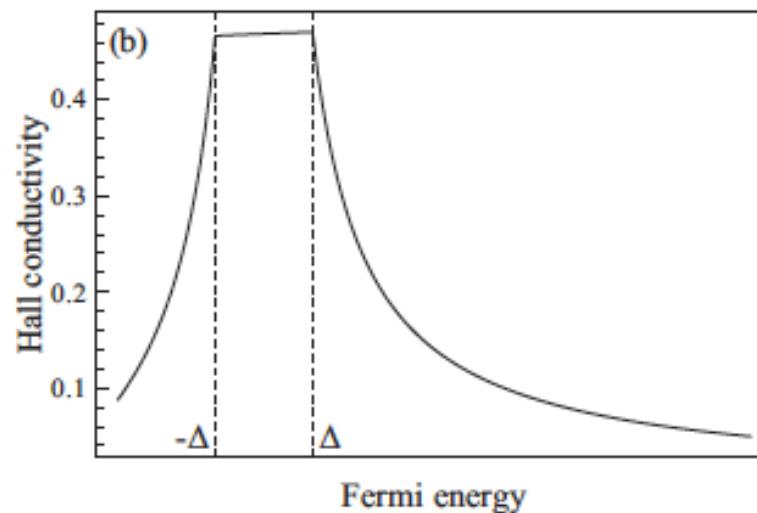
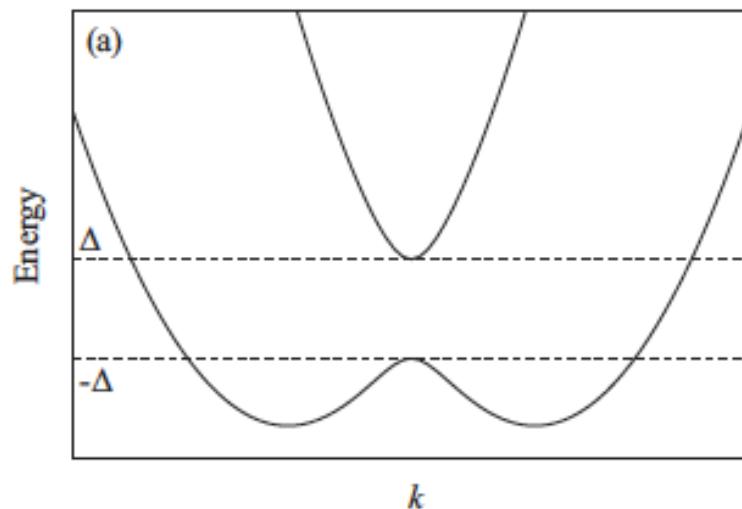
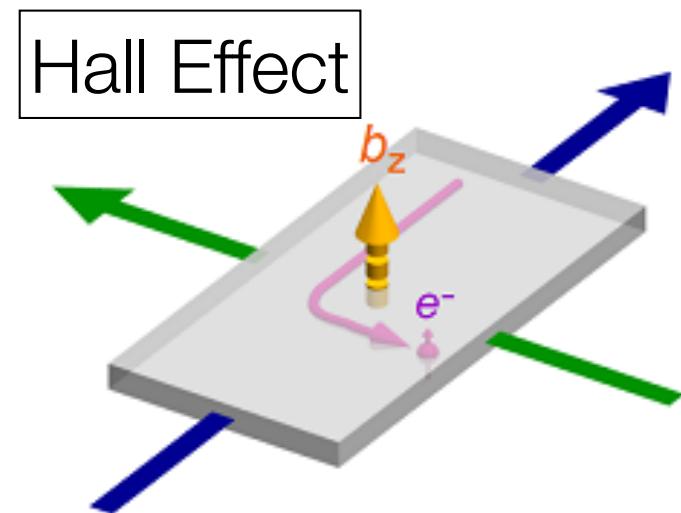
# The Anomalous Hall Effect

- Typically occurs in ferromagnets
- Extrinsic contribution
  - Skew-scattering
  - Side jump



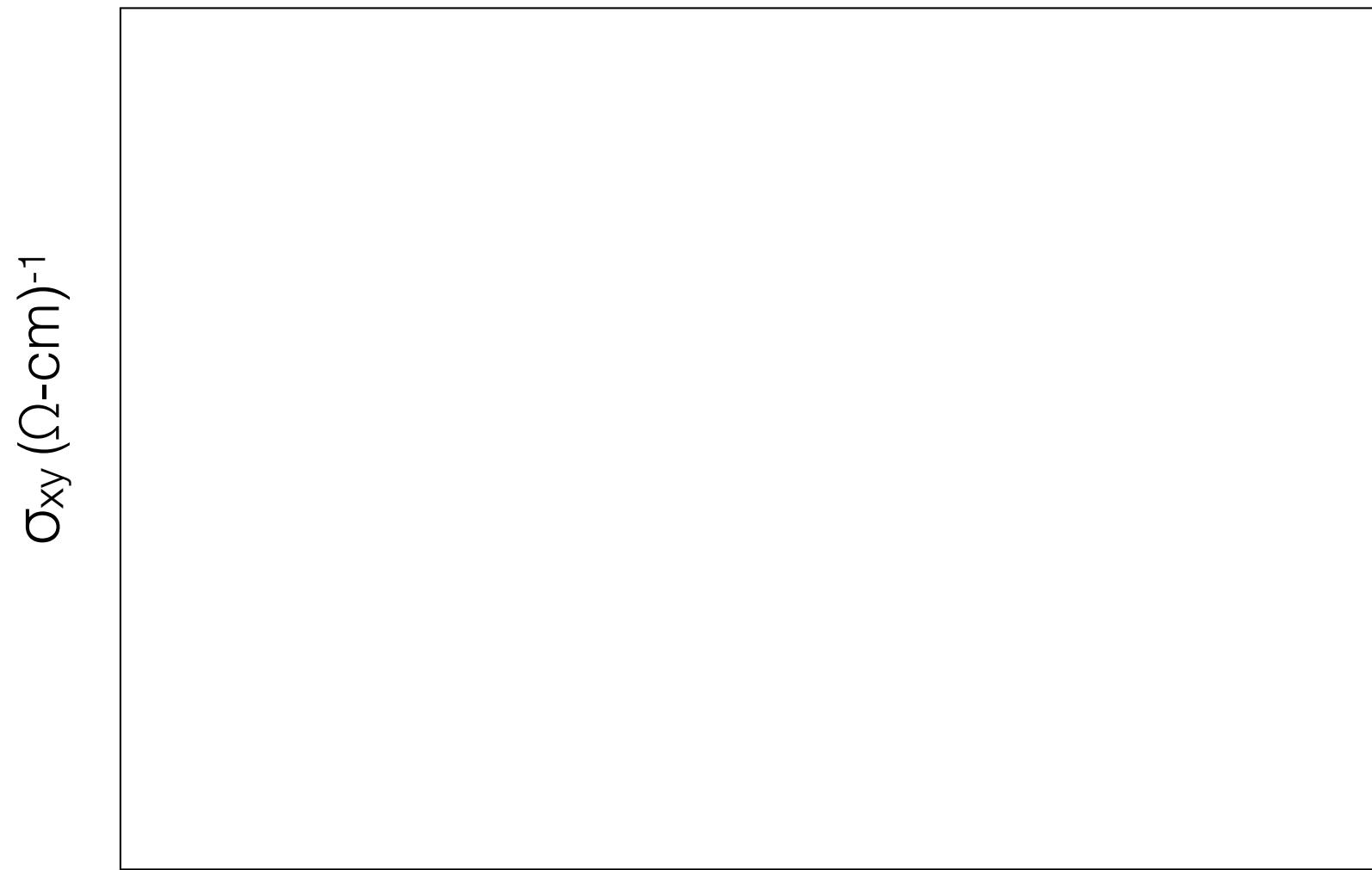
# The Anomalous Hall Effect

- Typically occurs in ferromagnets
- Extrinsic contribution
  - Skew-scattering
  - Side jump
- Intrinsic contribution (Berry curvature)
  - SOC opens gap
  - $E_F$  near gap, Hall conductivity enhanced



# Unified Scaling of the AHE in Ferromagnets

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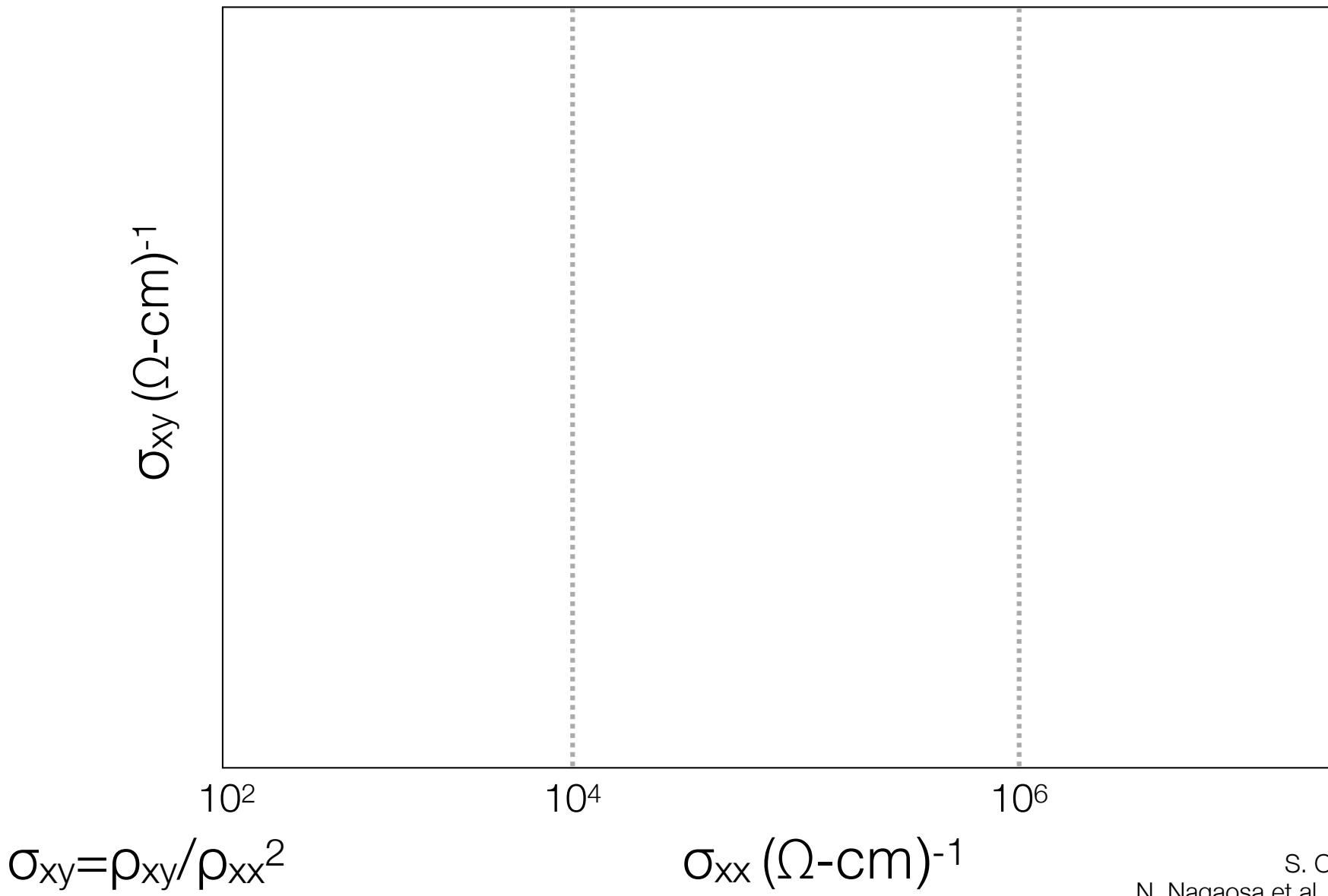
$$\sigma_{xy} = \rho_{xy}/\rho_{xx}^2$$

$$\sigma_{xx} (\Omega\text{-cm})^{-1}$$

S. Onoda et. al. *PRL*. 2006)  
N. Nagaosa et al., *Rev. Mod. Phys.*(2010)

# Unified Scaling of the AHE in Ferromagnets

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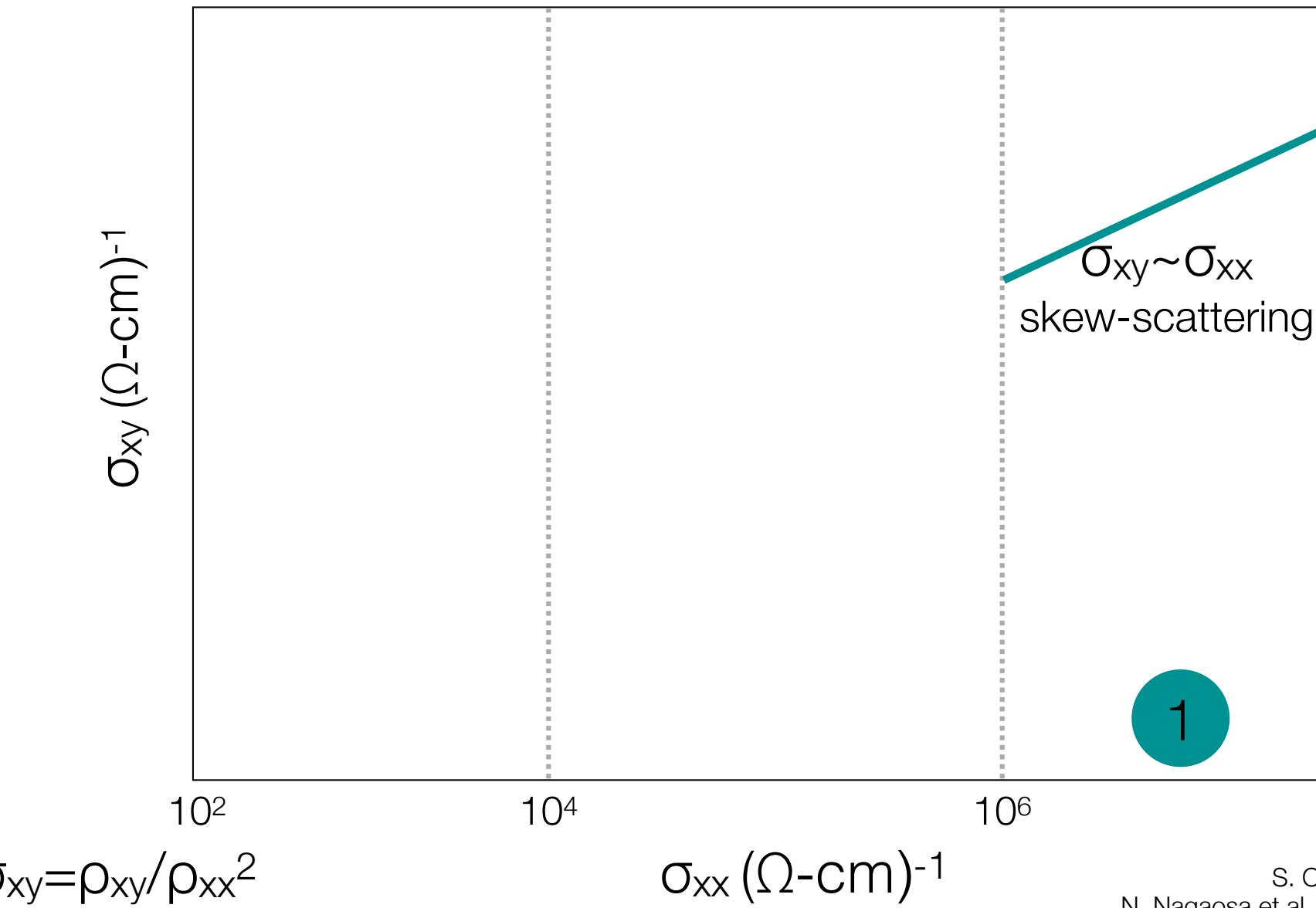


$$\sigma_{xy} = \rho_{xy}/\rho_{xx}^2$$

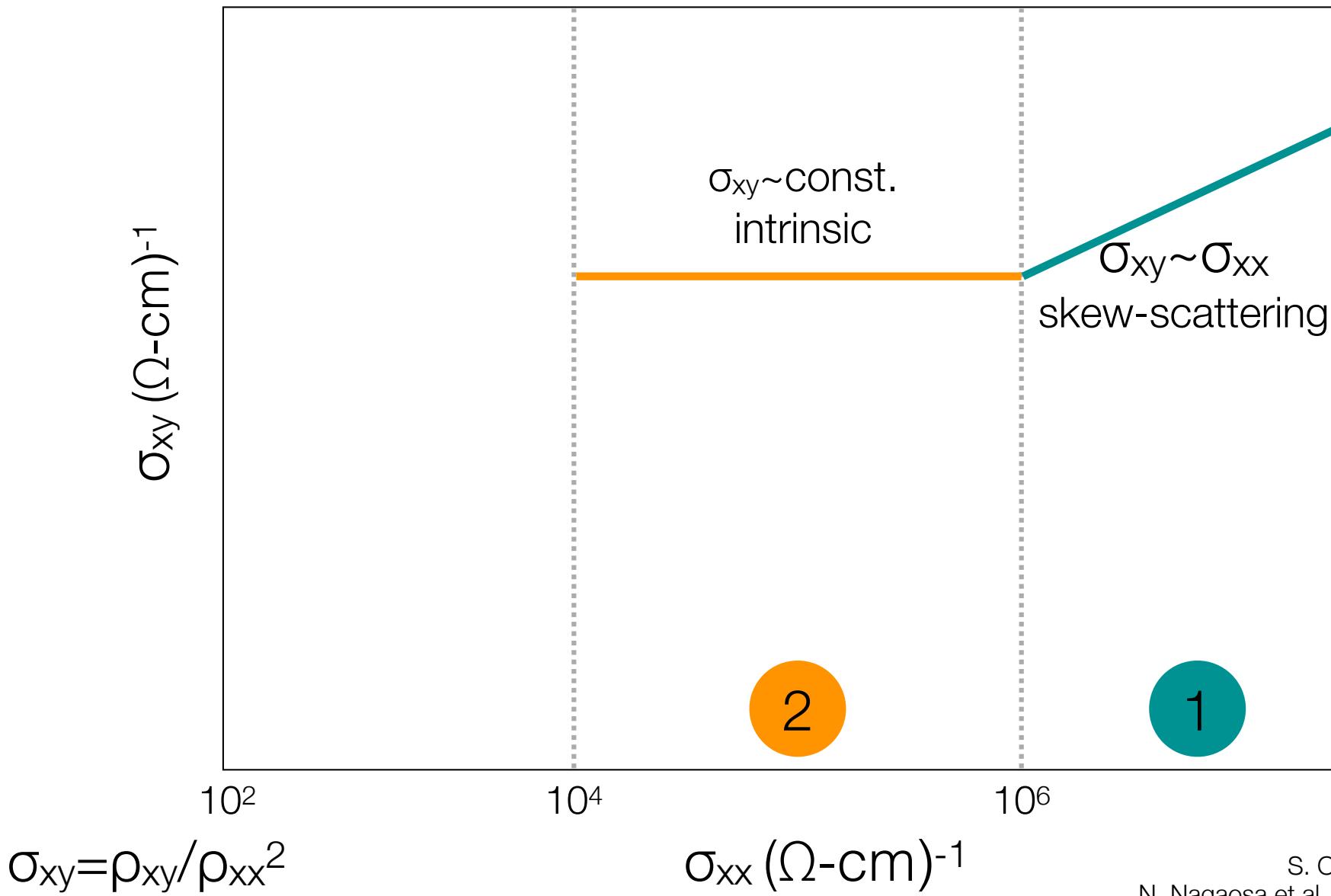
$$\sigma_{xx} (\Omega\text{-cm})^{-1}$$

S. Onoda et. al. *PRL*, 2006)  
N. Nagaosa et al., *Rev. Mod. Phys.*(2010)

# Unified Scaling of the AHE in Ferromagnets



# Unified Scaling of the AHE in Ferromagnets

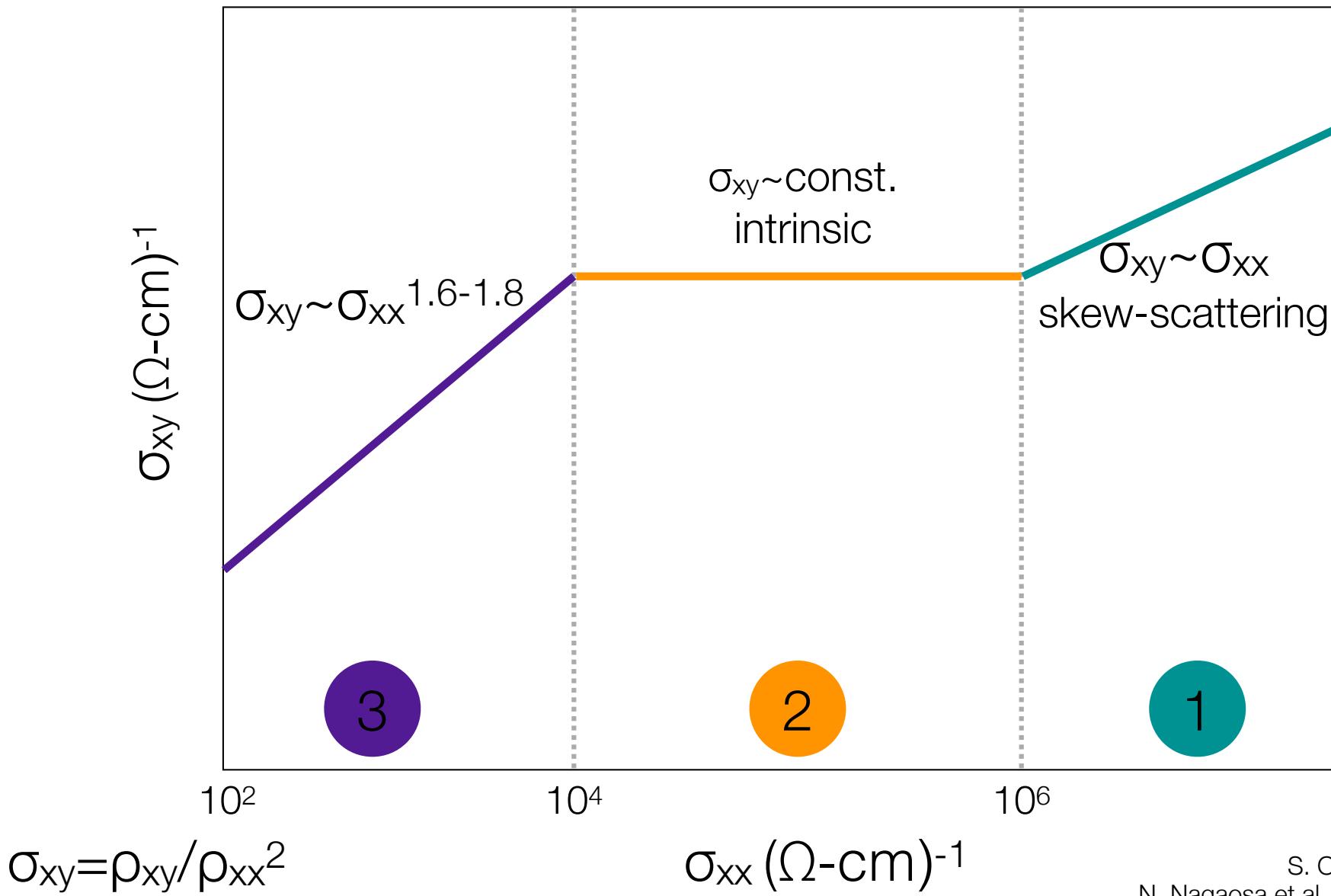


$$\sigma_{xy} = \rho_{xy}/\rho_{xx}^2$$

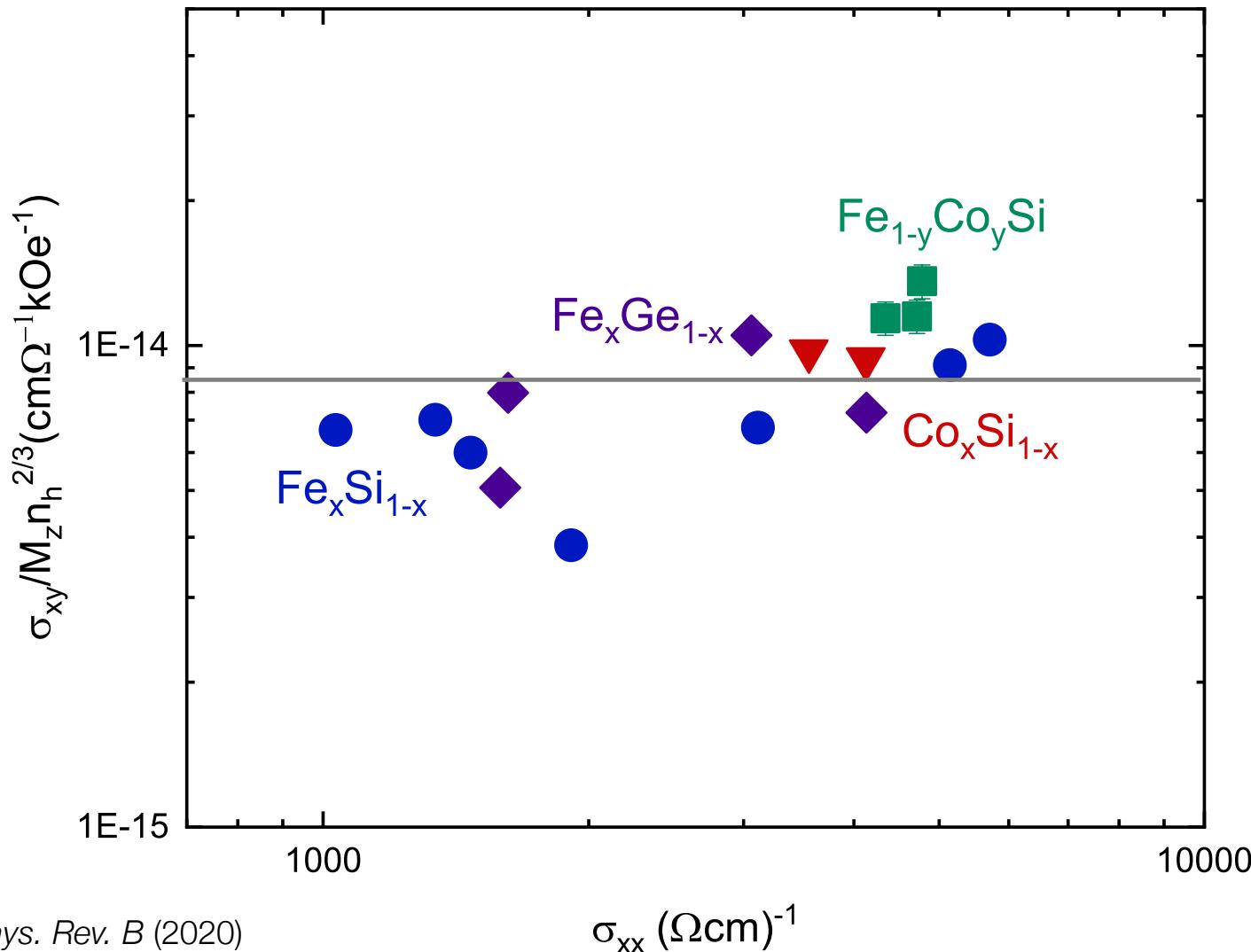
$$\sigma_{xx} (\Omega \cdot \text{cm})^{-1}$$

S. Onoda et. al. *PRL*. 2006)  
N. Nagaosa et al., *Rev. Mod. Phys.* (2010)

# Unified Scaling of the AHE in Ferromagnets



# Scaling of the AHE



# Intrinsic AHE

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- Independent of  $\sigma_{xx} \rightarrow$  Berry phase
- Indication of role of local structure

# Intrinsic AHE

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- Independent of  $\sigma_{xx} \rightarrow$  Berry phase
- Indication of role of local structure

PHYSICAL REVIEW B **95**, 121114(R) (2017)

## Locality of the anomalous Hall conductivity

Antimo Marrazzo<sup>1,\*</sup> and Raffaele Resta<sup>2,3,4,†</sup>

<sup>1</sup>*Theory and Simulation of Materials (THEOS), and National Centre for Computational Design and Discovery of Novel Materials (MARVEL), École Polytechnique Fédérale de Lausanne, CH-1015 Lausanne, Switzerland*

<sup>2</sup>*Dipartimento di Fisica, Università di Trieste, 34127 Trieste, Italy*

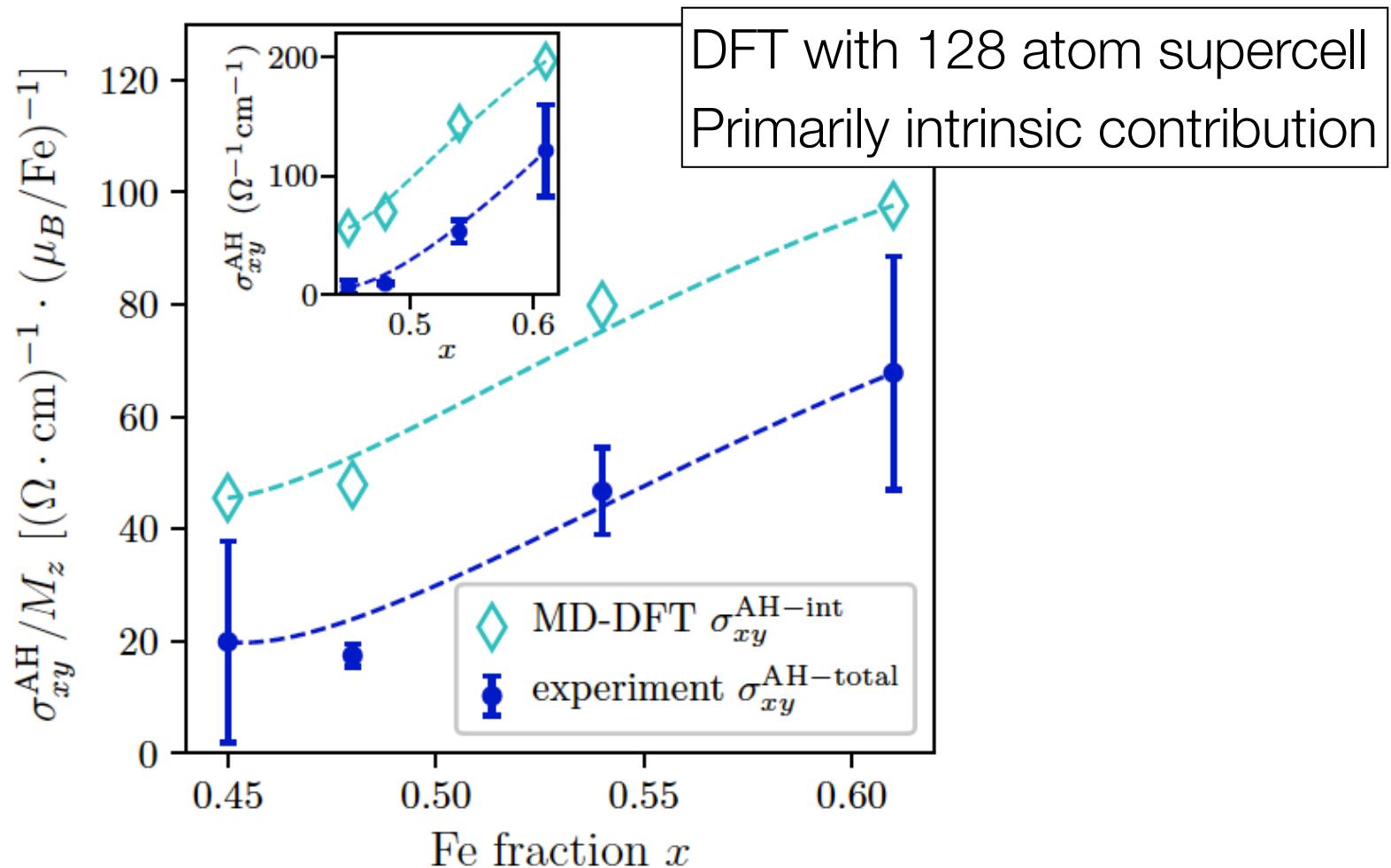
<sup>3</sup>*Consiglio Nazionale delle Ricerche (CNR), Istituto Officina dei Materiali (IOM) DEMOCRITOS, 34136 Trieste, Italy*

<sup>4</sup>*Donostia International Physics Center, 20018 San Sebastián, Spain*

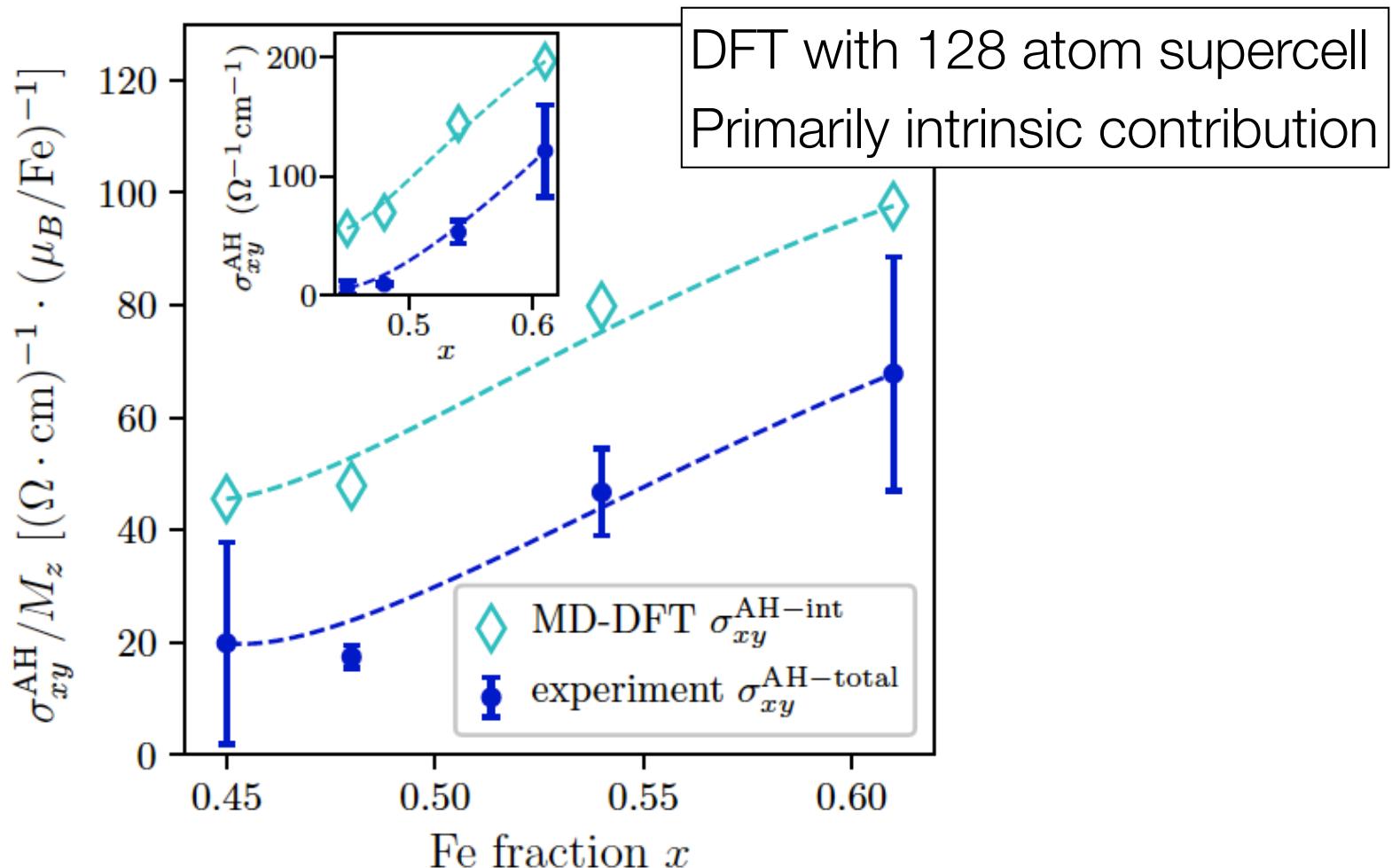
(Received 23 December 2016; published 31 March 2017)

Intrinsic AHC is local property of the electronic ground state and can be evaluated for samples where the concept of reciprocal space doesn't make any sense

# Intrinsic Hall Conductivity in Amorphous $\text{Fe}_x\text{Ge}_{1-x}$ and $\text{Fe}_x\text{Si}_{1-x}$

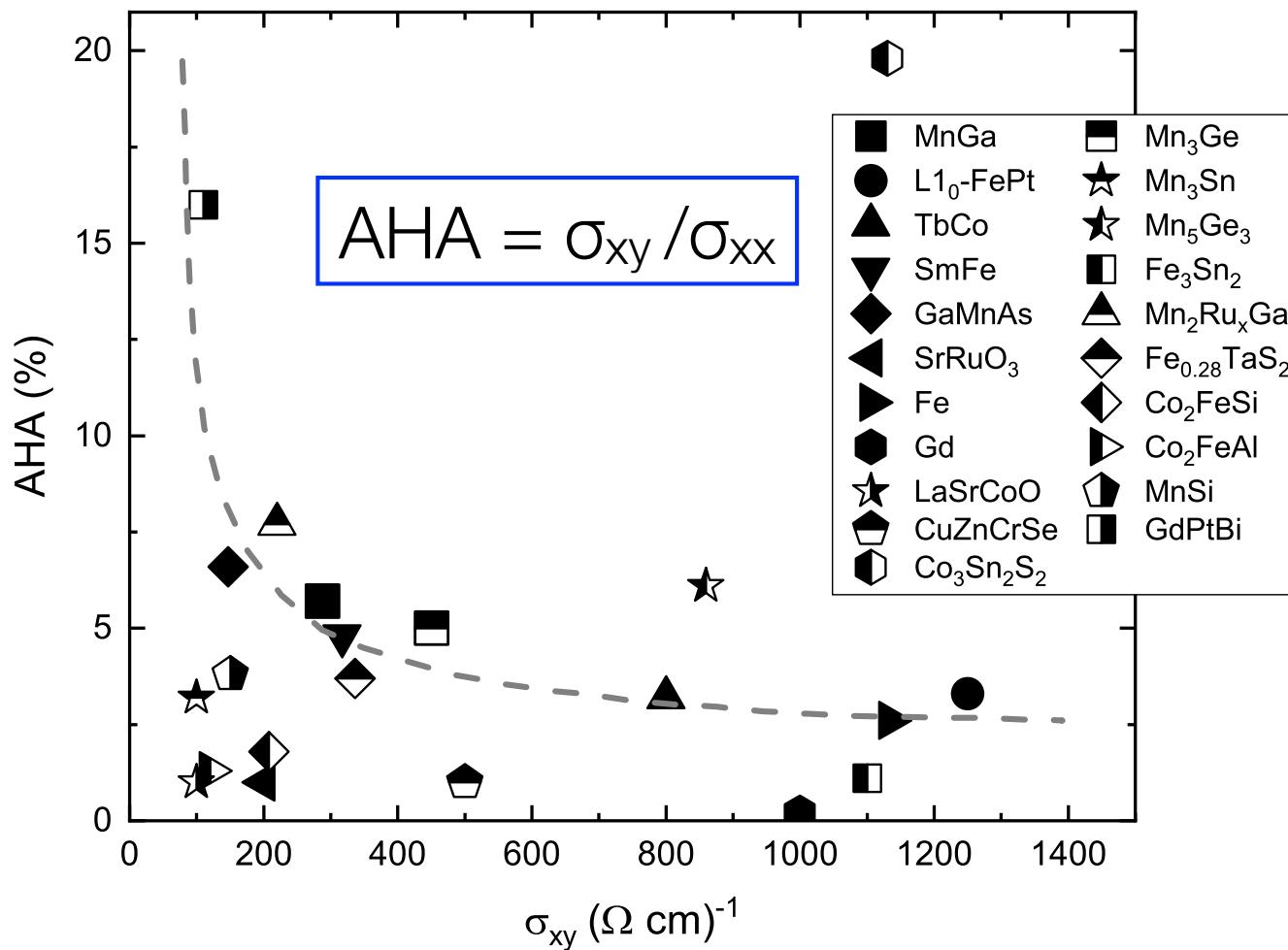


# Intrinsic Hall Conductivity in Amorphous $\text{Fe}_x\text{Ge}_{1-x}$ and $\text{Fe}_x\text{Si}_{1-x}$



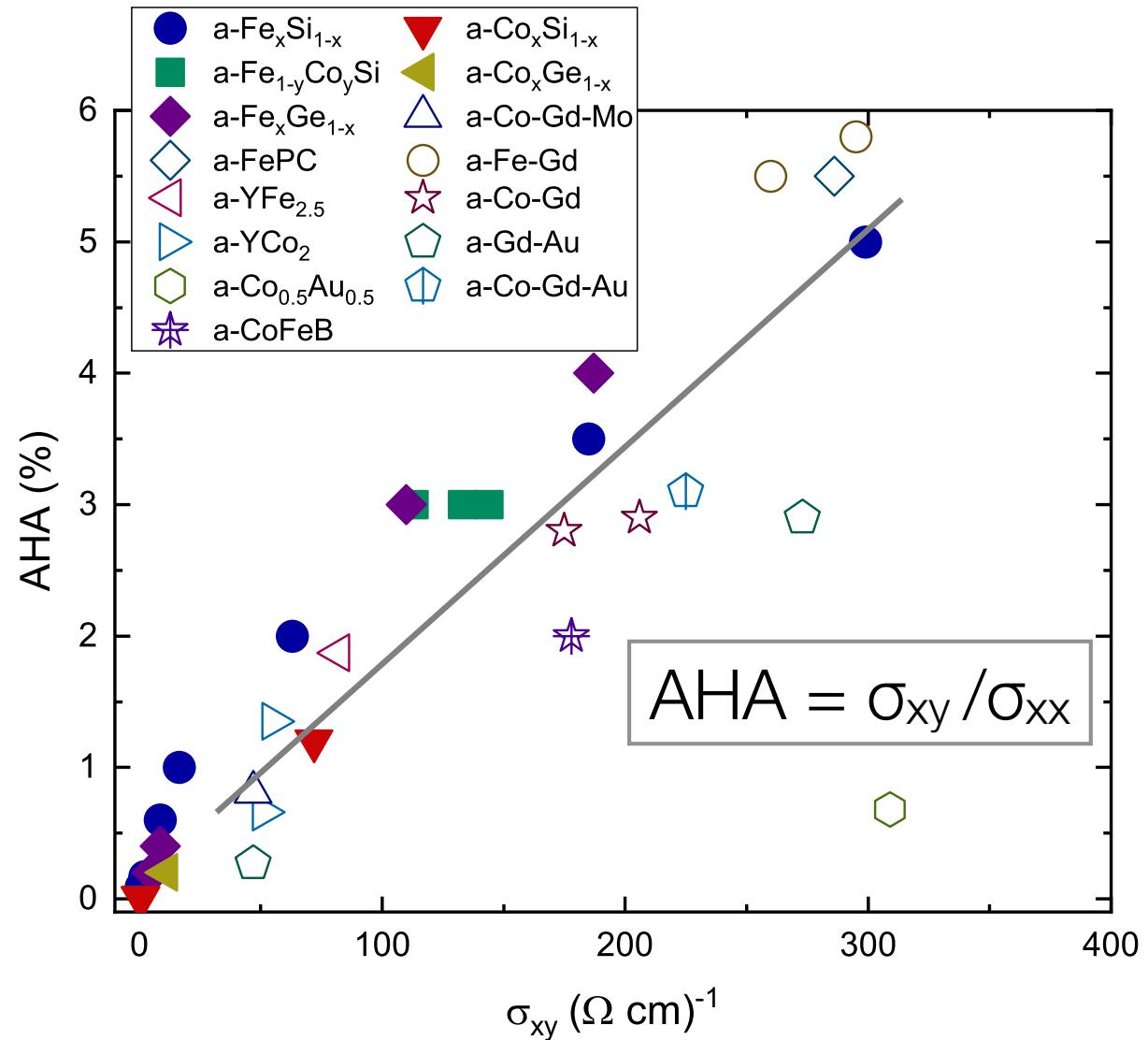
- Calculated amorphous  $\text{Fe}_x\text{Si}_{1-x}$   $x=0.50$ :  $\sigma_{xy}$  (intrinsic) =  $28 \text{ } (\Omega\text{-cm})^{-1}$
- Experimental result:  $x=0.55 \sigma_{xy} = 17 \text{ } (\Omega\text{-cm})^{-1}$  and  $x=0.57 \sigma_{xy} = 43 \text{ } (\Omega\text{-cm})^{-1}$

# Anomalous Hall Angle - Crystalline Materials



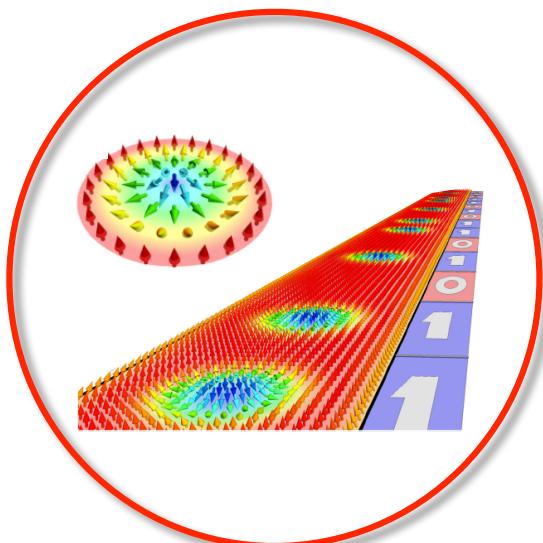
# Anomalous Hall Angle - Amorphous Materials

- AHA as large as 5%
- Driven by intrinsic mechanism
- Potential to increase further by increasing  $\sigma_{xy}$

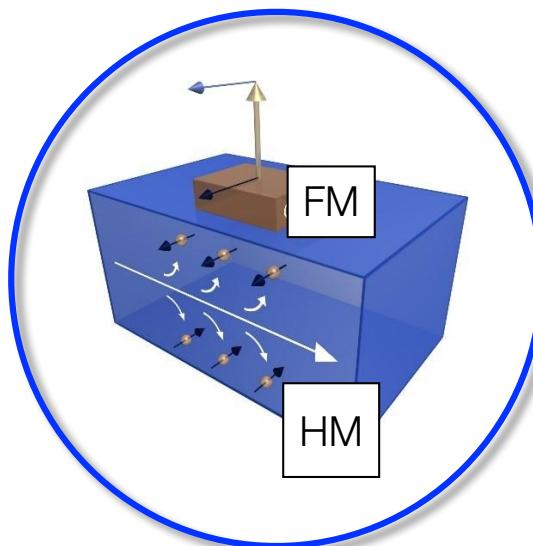


# Outline

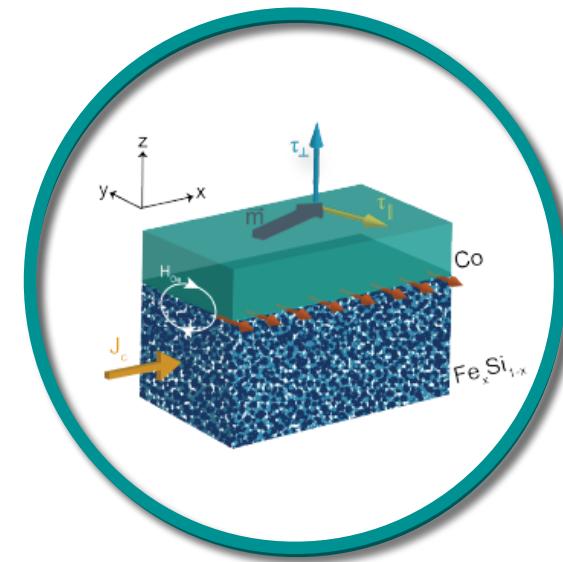
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Non-volatile memory  
and current  
challenges



Methods for spin  
current generation

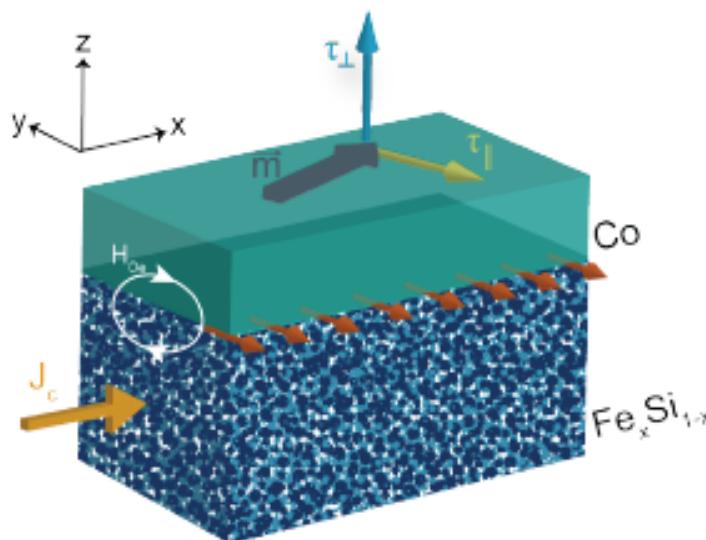


Using amorphous materials  
to create spin currents

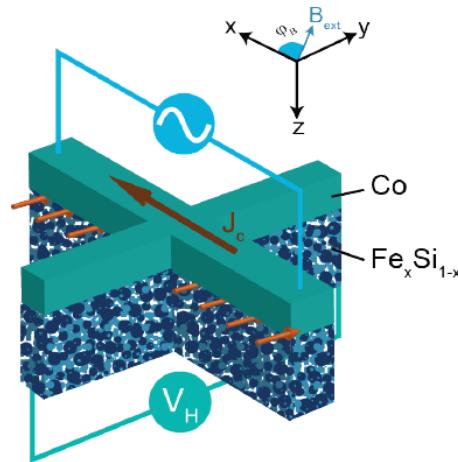
Ferromagnets  
Non-magnetic

# Spin Orbit Torques Generated by Amorphous $\text{Fe}_x\text{Si}_{1-x}$ Thin Films

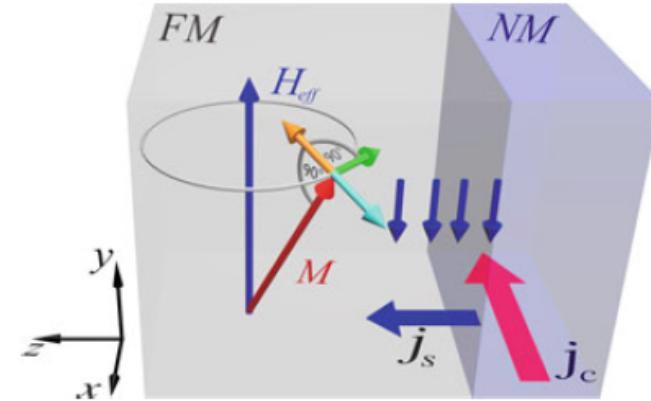
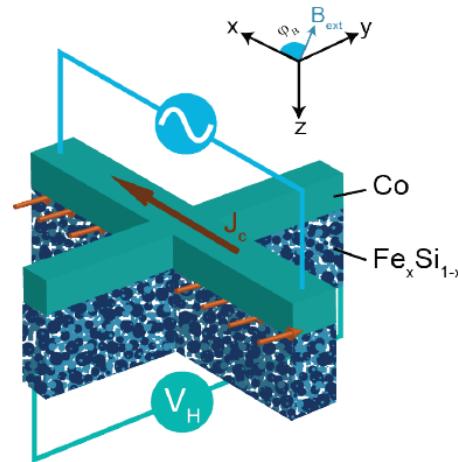
- Harmonic Hall and spin torque FMR measurements at room temperature
- Amorphous  $\text{Fe}_x\text{Si}_{1-x}$  ( $x=0.40, 0.45$ ); paramagnetic at room temperature
- Extract spin orbit torque efficiency,  $\xi$



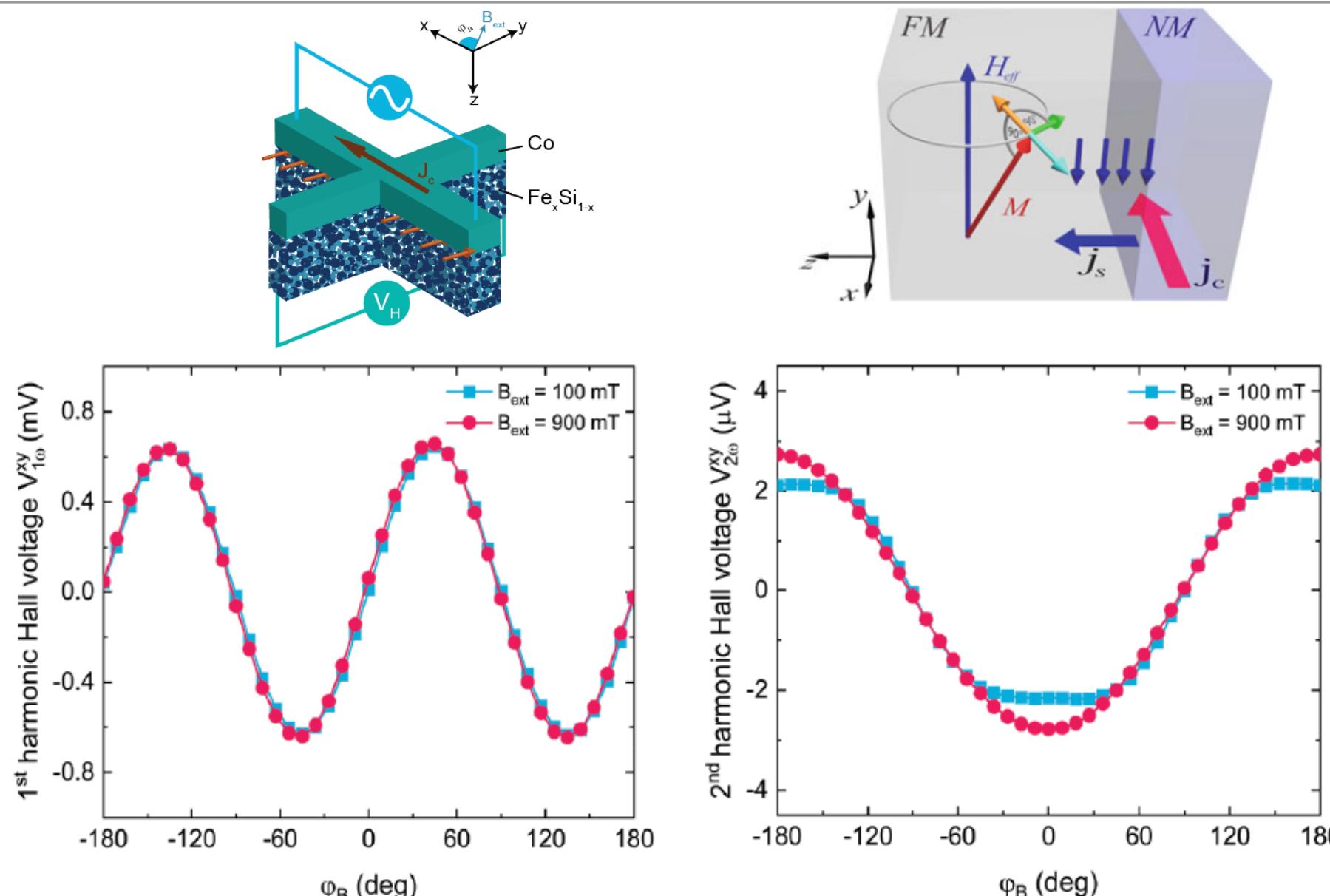
# Harmonic Hall Measurements



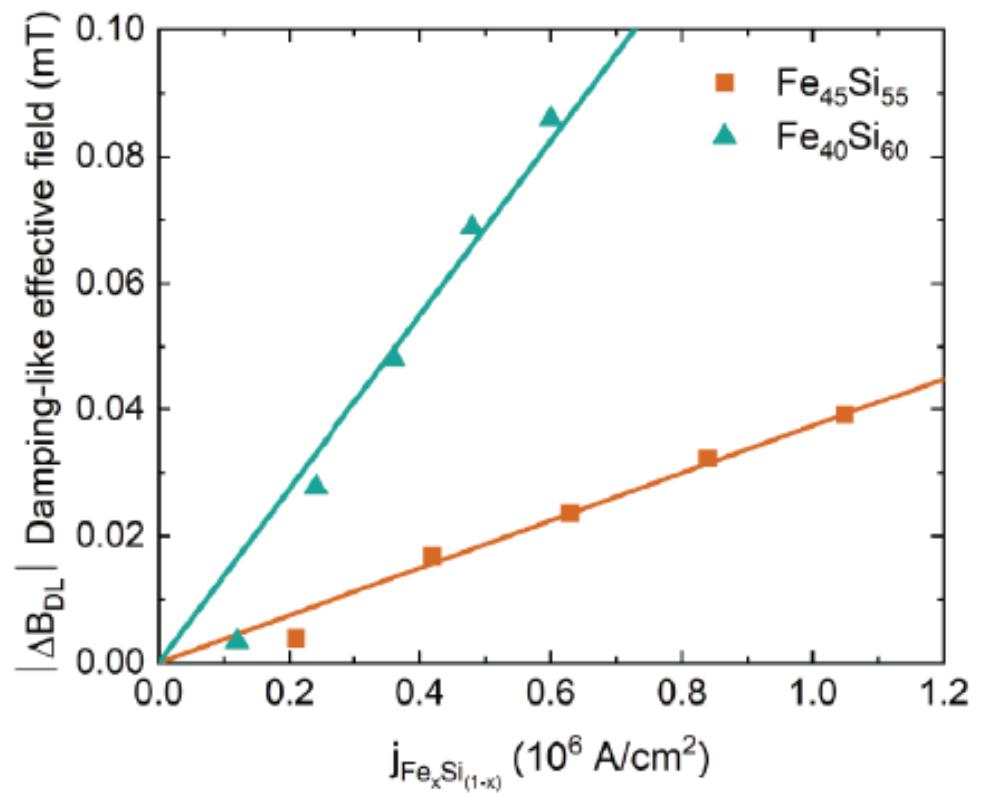
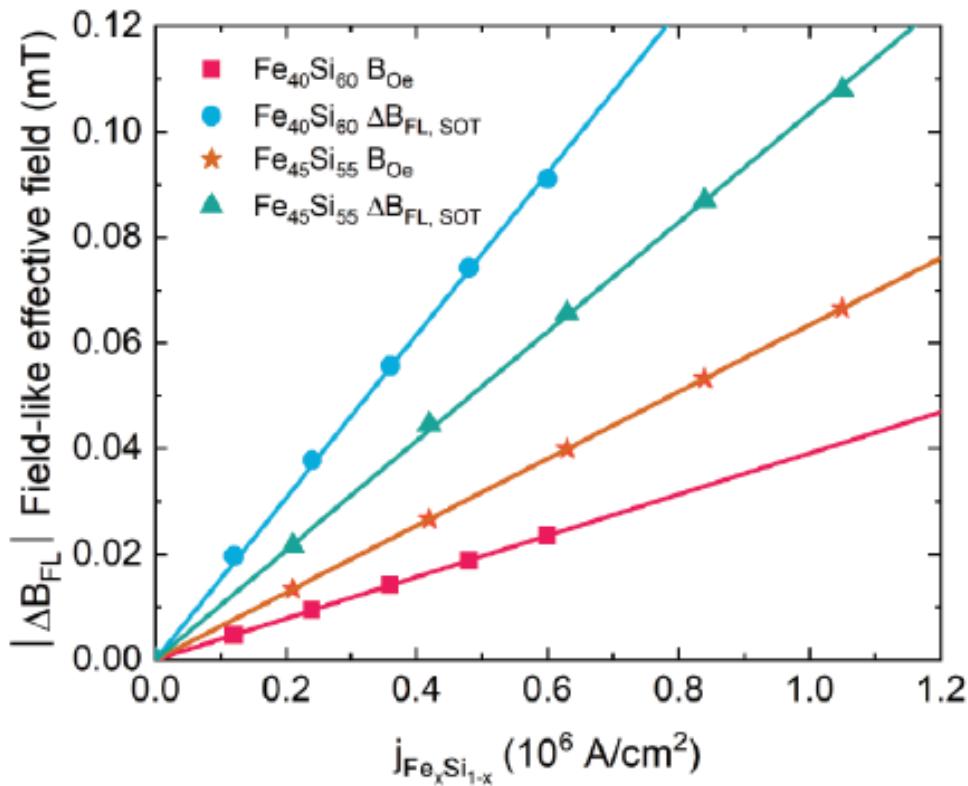
# Harmonic Hall Measurements



# Harmonic Hall Measurements

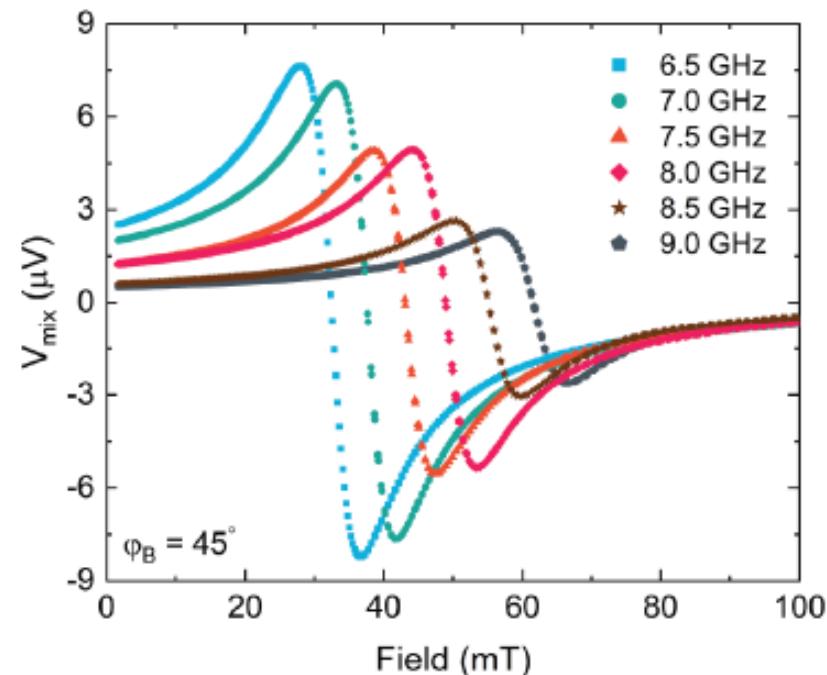
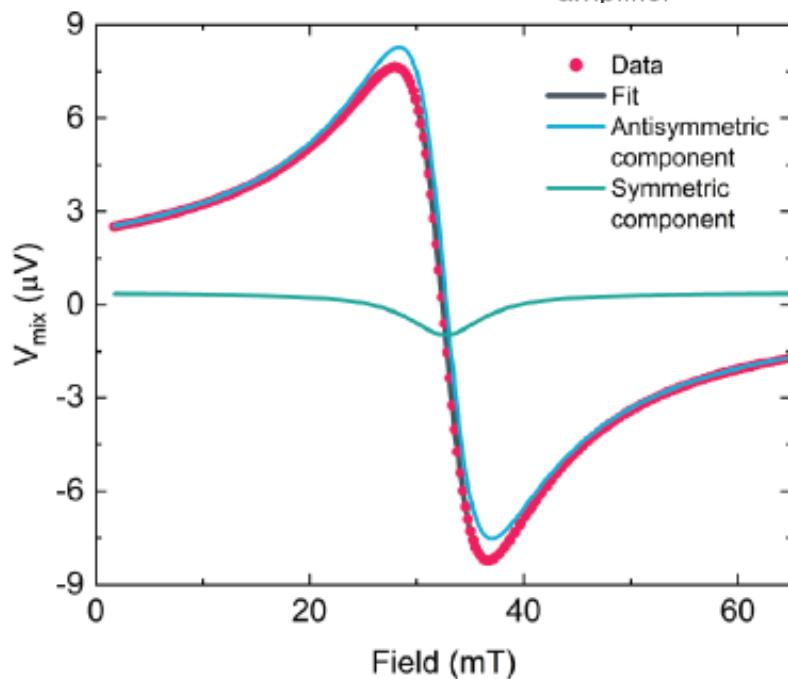
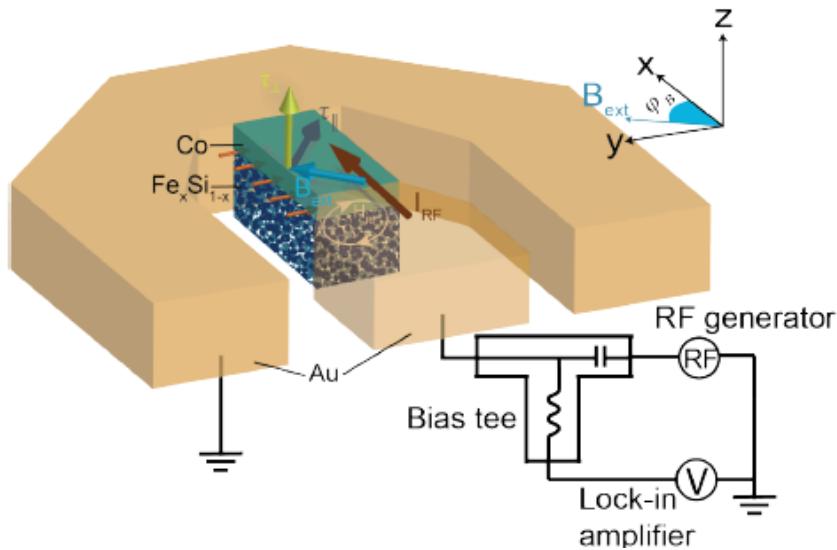


# Harmonic Hall Measurements



$$\begin{aligned}x &= 0.40 \quad \xi = 11.92\% \\x &= 0.45 \quad \xi = 3.98\%\end{aligned}$$

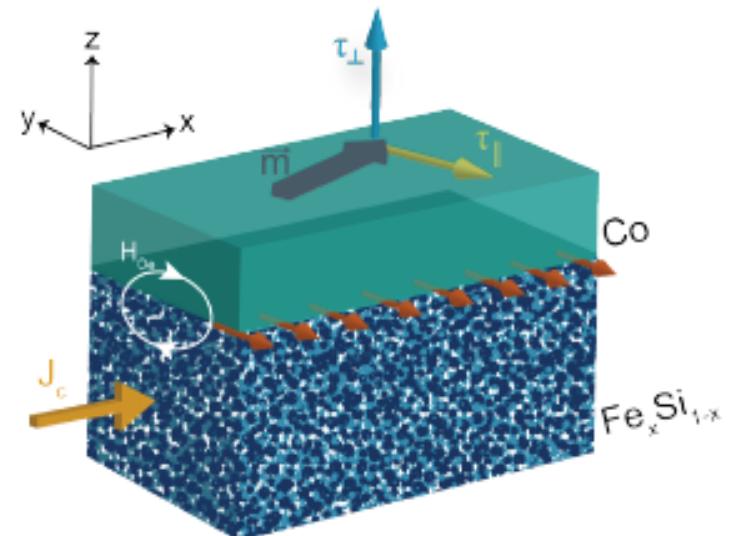
# Spin-Torque Ferromagnetic Resonance



$$\begin{aligned}x &= 0.40 \quad \xi = 4.32\% \\x &= 0.45 \quad \xi = 2.56\%\end{aligned}$$

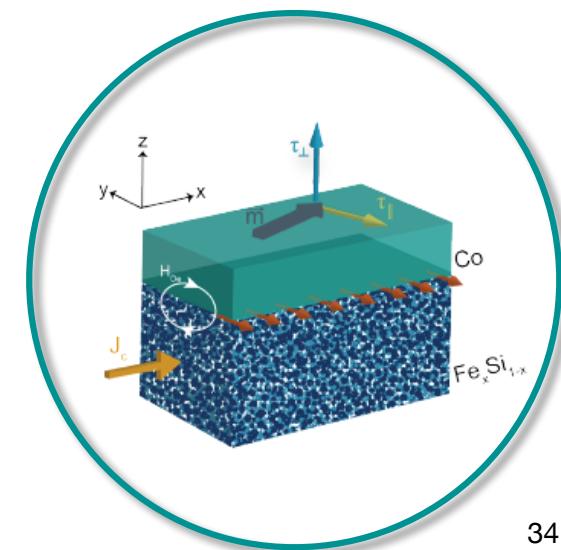
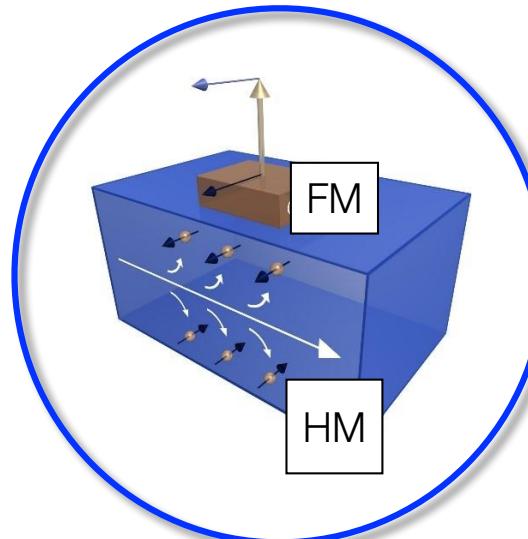
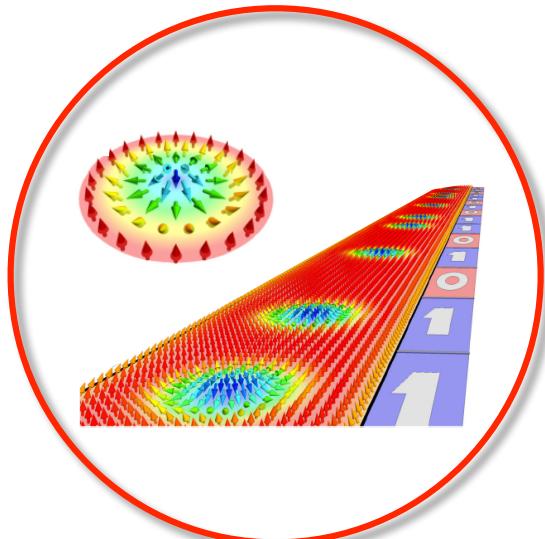
# SOT Measurement Summary

- Amorphous  $\text{Fe}_x\text{Si}_{1-x}$  exhibits SOT,  $\xi \sim 3\text{-}12\%$ 
  - Crystalline p-type Si  $\xi \sim 0.01\%$
  - Pt  $\xi \sim 8\%$
- Need to understand more about origin of large SOT



# Concluding Remarks and Future Work

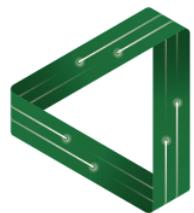
- Efficient spin current generation critical to numerous low-power data storage and logic devices
- AHA greater than or equal to crystalline materials
- Spin orbit torque efficiencies  $\sim$  Pt
- Potential to further improve
  - Amorphous  $\text{Bi}_2\text{Te}_3$



# Acknowledgements



**Australian Government**  
**Australian Research Council**



**F L E E T**  
ARC CENTRE OF EXCELLENCE IN  
FUTURE LOW-ENERGY  
ELECTRONICS TECHNOLOGIES

Discovery Project DP200102477



**UC-Berkeley**



Frances Hellman



Sayeef Salahuddin



**UC-Irvine**



Ruqian Wu



**MONASH**  
University



Golrokh Akhgar



Alex Nguyen



Abu Parvez



Scott Bennett



Sandy Awad



Sally Sprague



Daniël van Tubbergh